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(54) Title: MODIFIED FILLER PARTICLES AND SILICONE COMPOSITIONS COMPRISING THE SAME

(57) Abstract: Composition of comprising nano metal oxide/hydroxide particles and a polyorganosiloxane having increased refractive index, processes to cure these compositions for making transparent coats, shaped articles by an extrusion or molding process having a refractive index above the refractive index of the polyorganosiloxane. Use of the cured polyorganosiloxane compositions as optical devices, coats, lenses or light guides.



MODIFIED FILLER PARTICLES AND SILICONE COMPOSITIONS COMPRISING THE SAME

CROSS-REFERENCE TO RELATED APPLICATIONS

5 The present application claims priority to U.S. Provisional Application No. 62/194,545, entitled "Modified Filler Particles and Silicone Compositions Comprising the Same," filed on July 20, 2015, the disclosure of which is incorporated herein by reference in its entirety.

FIELD

10 The present subject matter provides a composition of polyorganosiloxanes nano crystalline metal oxides or hydroxides, and a process to disperse or crystallize these particles. The curable composition with the dispersed, optionally surface modified particles shows high refractive indices at good light transmission. The composition is suitable for the use in a variety of applications such as optical devices or light guides. The work leading to this invention has
15 received funding from the European Union Seventh Framework Program (FP7-NMP-2010-LARGE-4) under "grant agreement" n° 263382.

BACKGROUND

Polyorganosiloxane polymers or copolymers having a high refractive index have been
20 increasingly used for a variety of optical applications including, for example, in contact lenses, intraocular lenses, LED lenses etc. Such polymers are also finding their way into other optical applications requiring high transmission and high refractive index including but not limited to, solid state lighting (light emitting diodes, organic light emitting diodes, laser diodes), waveguides (both planar and "fiber" geometries), optical computing, optical storage media,
25 antireflection coatings, conformal coatings, optical lenses, micro lenses, automobile topcoats, paint formulations, hair-care products, gradient refractive index optical components, dynamic gradient refractive index components, etc.

Depending on the application, the polymers and their cured compositions such as shaped articles may need to exhibit a wide range of properties including sufficient structural integrity,
30 strength, elasticity and elongation, outstanding index of refraction, etc. Although the refractive

index of usual polydimethylsiloxanes can be increased by specific substituents the achievable level is limited. It has been therefore proposed to disperse high refractive oxides in such polymers in order take advantage of the higher refractive index of the high refractive oxides. However, such concepts failed to give polyorganosiloxane compositions that provide the desired light transmission and in the same time an increased refractive index. There is always a conflict between the desirable high concentration of high refractive additives such as fillers, e.g. nano particles of oxides and the ability to end up with compositions which are applicable by known coating or injection processes for the manufacture of films or shaped articles. Many of these compositions suffer either on the particle size which are too big in size or tend to agglomerate at least under storage over the time or defects of optical properties. There was no clear conclusion on whether the refractive indices cannot get adjusted to the desired light transmission, agglomeration is an issue or sedimentation is the reason for failure. Without bond to theory it is believed that any have to do with one of these reasons.

In addition the composition comprising high refractive oxide must be handy in usual processes for the manufacture of films, coatings, shaped articles made by an extrusion or molding process. These process requirements need to design in addition the flow properties such as viscosity. In some applications, the polymers must exhibit these properties when formed into a thin film. For example, in intraocular lenses, the lens must be thin and pliable for insertion through a small incision in intraocular lens applications, and have sufficient structural integrity and strength to retain such shape under normal use conditions. It is desired to have a transmission of more than 90 % for light with a wavelength between 300 to 1800 nm at thickness of 2 mm over more than 6 months. The refractive index of the composition shall be more than 1.55 measured as n_D^{20} whereby the viscosity of the composition shall not exceed 50 000 000 mPa.s at 25 °C at a shear rate of $D=10 \text{ sec}^{-1}$.

One approach to increase the refractive index of binder polymer includes the use of a crystalline nano metal oxide in e.g. acrylate composition as disclosed in WO 2012/058271 A2. The examples are silent about the transparency of the composition in thick layers. It could be shown that improvements in transparency are still necessary for some of these materials.

There are many proposals in the prior art which substituents could be suitable for increasing the refractive index of polyorganosiloxanes. Some of the possible substituents are shown in WO 2014-152686 and WO 2013-172921 (Dukes et.al.).

A very well-known way is the use of phenyl substituted siloxanes as a polymer with increased refractive index. For example the introduction of aromatic groups results in dimethylsiloxane-phenylmethylsiloxane co-polymers or dimethylsiloxane-diphenylsiloxane co-polymers which are suitable candidates for polymers having an increased refractive index. Despite the positive effect on the refractive index, the introduction of refractive index modifying groups, such as phenyl-groups, in polyorganosiloxanes is known to result in several important disadvantages.

High concentrations of phenyl groups are however necessary to achieve higher refractive indices. Polyorganosiloxanes having more than 5 mol.% of phenylsiloxy groups have the tendency to crystallize and to be solid at room temperature. Additionally, increasing the phenyl content in polyorganosiloxanes leads also to a significant increase in the viscosities of such polymers in particular when used in compositions with fillers limits their processability.

Nevertheless the increase of the refractive index is limited to about n_D^{20} of 1.6 for 100 mol.% for *e.g.*, diphenylsiloxy units respectively for diphenylsiloxanes in addition such polymers could be solid at 25°C or have at least a high viscosity, whereby usual fillers such as silicas can limit the refractive index of these polymers in composition down to about n_D^{20} of 1.54 at 25°C and increase the viscosity for another time. A good processability can only be achieved if a certain level of low viscosity at 25 °C is provided. Injection molding processes or extrusion processes may tolerate a higher viscosity than casting or film coating processes.

In addition, the pure polyorganosiloxanes containing phenyl groups without a reinforcing filler or a similar reinforcing resin is not suitable for the manufacture of articles wherein a certain level of mechanical strength is desired.

The inventors found a way to overcome the weakness of known systems with high refractive transparent compositions, wherein the filler is provided as stabilized dispersion and the light transmission adjusted as desired.

SUMMARY

The present subject matter provides a composition of nano crystalline metal oxides (A) or hydroxides and polyorganosiloxanes (B), a process to disperse or crystallize these particles. The invention discloses curable compositions with dispersed nano crystalline optionally surface modified particles which are showing high refractive indices and good light transmission in a broad range of wavelengths. There is also disclosed a process how the compositions can be cured. The compositions are useful for the manufacture of a variety of applications such as optical devices, lenses or light guides. In one aspect, the inventive compositions make use of an asymmetrically substituted polyorganosiloxane as binder as well as dispersing aid which can stabilize the dispersion of the filler and adjust the light transmission.

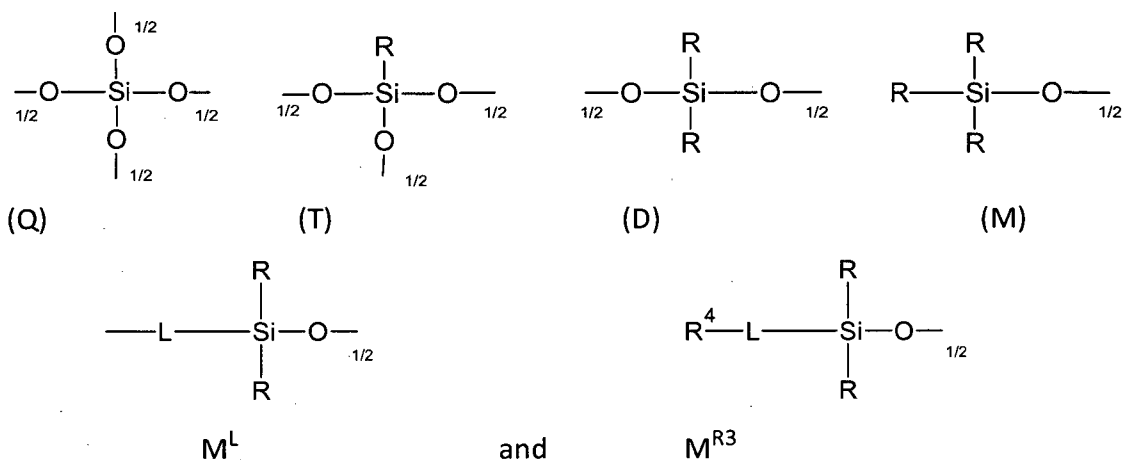
In one embodiment, the asymmetrically substituted polyorganosiloxane has the formula $R^4 - \{ -L[SiR_2O]_p - SiR_2 \}_m - L - R^{4*}$, wherein the polyorganosiloxane has two different terminal groups.

The inventors have found polyorganosiloxanes which are useful as binder polymer having increased refractive index and can disperse and stabilize this dispersion than polyorganosiloxanes known in the state of the art.

The inventors have found a threshold value for the difference between metal oxide and the polyorganosiloxanes which allows minimizing the amount of expensive groups necessary for an increased refractive index and enough light transmission. In addition it was found that use of an asymmetrically substituted short chain polyorganosiloxane can at least disperse and stabilize the high refractive oxides in a binder polymer. It is even possible to use the asymmetrically substituted short chain polyorganosiloxane as binder polymer itself, since it allows the incorporation of high amounts high refractive oxides and can be furnished with reactive groups which can undergo curing reactions with each other.

DETAILED DESCRIPTION

The invention discloses a composition comprising metal oxide/hydroxide particles (A), one or more of a polyorganosiloxane (B), (B1) and (B2) selected from the group which consists of one or more substituted polyorganosiloxanes having units of the formulas (I),



wherein R are selected from the group of R¹ and R², R³, R⁴, L, and

R¹ is selected from the group which consist of monovalent C1 to C22-alkyl, optionally substituted by Cl or F, and

R² which is selected from the group consisting of monovalent unsubstituted or substituted alkenyl groups selected from C2-C22-alkenyl, and including R²² which selected from C6-C22-cycloalkenyl, C7-C22-bicycloalkenyl, C6-C22-alkenylarylalkyl, optionally substituted by R¹, bonded via a carbon atom of a hydrocarbon group to the silicon atom of the siloxy unit, which may be interrupted by O, N atoms, and

R³ is a group -L-R⁴ forming M^{R³} of formula (I), wherein

R⁴ is selected from the group of R¹, R², R²², hydrogen, and a monovalent substituted or unsubstituted C4-C30-hydrocarbon unit optionally interrupted by -NR⁹-, O, S or P atoms, substituted with R¹, OH, Cl, F, CN, OR⁹- consisting of C1-C22-alkyl, poly (F)-alkylene oxide R⁹ terminated,

(R¹X)_xR¹_{3-x}Si-, x= 1-3, X= C1-C8 alkoxy, C1-C8-alkylcarboxy, C1-C8-alkylamino, and

an ionic group derived from esters of carboxylic acids, S or P acids such as

R⁹-C(O)-O-, (R⁹-O)₂-P(O)-O-, (R⁹-O)₂-P(O)-, (R⁹-O)₂-P-O-, -NHR⁹-CH₂-COOH,

-NHR⁹-CH₂-O-S(O)₂(OH), -S-S(O)₂(OH)₂, whereby R⁹ is= hydrogen, C1-C8 alkyl, C2-C8-alkenyl, me₃Si-,

and acid salts of amines, phosphines or preferably salts having quaternary -N⁺R⁹₃ or -P⁺R⁹₃ groups,

and including R⁴² selected from the group of R²², C6-C22-cycloalkyl, C6-C12-cyclothioalkyl, C7-C22-bicycloalkyl, C6-C22-aryl, C5-C12-hetero-N, -O, -S-aryl, C8-C22-polycyclic aryl, C7-C22-alkylaryl, C7-C22-arylalkyl, C8-C22-arylalkylene-arylalkyl, epoxides, of the group R², R²², and

R⁶_xR¹_{3-x}Si-, wherein x = 1-3,

R⁶= C6-C10-aryl, C7-C12-arylalkyl, C6-C12-cycloalkyl, C7-C16-bicycloalkyl, epoxy C3-C12-epoxy alkyl, C6-C12-cycloalkyl, epoxy C7-C16-bicycloalkyl, C6-C12-thiocycloalkyl, C5-C12-hetreo-N,-O, -S-aryl,

bonded via a single bond or carbon bond of L to the silicon atom of the siloxy unit, whereby

L is a single bond, a divalent or trivalent group, which is selected from the group which consists of C1 to C12-alkylene groups, which can be interrupted by one or more O, - or -NR⁹-C(O)-, and/or -NR⁹-, urethane -OC(O)NR⁹-, urea -NR⁹HC(O)NR⁹-, moieties, and substituted by one or more OH groups, bonded via a carbon bond to the silicon atom of the siloxy unit,

optionally one or more crosslinker (C) selected in addition from the group of silicon-free unsaturated C6-C30- hydrocarbons having more than 2 unsaturated groups, C6-C30- hydrocarbons having epoxy groups selected from the group of (B) consisting of the polyorganosiloxanes (B2) having an additional group R⁷, wherein R⁷ is hydrogen attached to Si (SiH),

optionally one or more of a curing catalyst (D) selected from the group of radical initiators, hydrosilylation catalysts, condensation catalysts, catalysts for light-activated cationic polymerization,

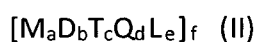
characterized in that at least one component (B) comprises more than 5 mol.% siloxy units which are substituted with R^{22} and R^{42} and has a refractive index n_D^{20} of more than 1.43.

The inventors have found that the shortcomings of the compositions comprising metal oxide/hydroxide particles and polyorganosiloxanes as binder or matrix polymer could be removed. The invention provides a polyorganosiloxane composition which has a reasonable processability and in which the optical properties of the dispersed metal oxide/hydroxide nano particles can be stabilized. Previous problems of such compositions are resolved by the use of specific polyorganosiloxanes having selected structures and substituents.

The appropriate groups are selected from substituents useful for curing the polymer and groups which provide enough optical density respectively high refractive indices. In some embodiments of the invention both features can be realized with one substituent. The term metal oxide/hydroxide particles in this invention means nano-sized oxides with particles sizes below the wavelength of visible light. Some of the available particles are offered commercially as dispersion in a solvent and have already any added dispersion aid. Although the particle size of such nano metal oxides is in the desired range, the compositions state of the art with polyorganosiloxanes comprising them do not show perfect transparency respectively a sufficient light transmission over a broad range of wavelengths and over a longer period of time.

The inventors found a composition comprising a polysiloxane which is stabilizing the high refractive nano metal oxide particles against agglomeration and sedimentation and can overcome this problem present in previous compositions.

The novel polyorganosiloxanes of the invention are enabling the manufacture and use of compositions which provide a reasonable stability against agglomeration, sedimentation of the metal oxide particles and are showing good optical properties like light transmission over a broad range of wavelength and in thick sections. The compositions include a polyorganosiloxane (B) comprising the units M, D, T and Q, having the structure of the empirical formula (II)



wherein:

$a = 0$ to 6,

b = 0 to 2000,

c = 0 to 50,

d = 0 or 1

e = 0 to 6

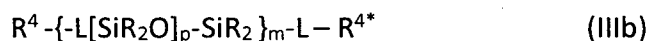
f = 1 to 200, if d = 1 or Q is present

wherein $a + c + d > 0$, and the viscosity at 25 °C is below 200 000 mPa.s at a shear rate at $D=10 \text{ sec}^{-1}$.

The empirical formula may express that the selected structures of the polyorganosiloxanes are suitable in particular for the inventive composition. These types of polymers comprise linear and branched structures of relative low molecular weight. In view of the cost aspect and the amount of expensive groups R^2 , R^3 , R^4 and R^6 in particular the so-called optical dense groups R^{22} and R^{42} , which have a high impact on the overall refractive index and therefor shall be selected under the aspect of highest efficiency with respect to the overall costs. It was found that a threshold value of the refractive index n_D^{20} should exceed 1.43 in order to achieve a higher refractive index of 1.6 to 1.7 of the total composition under incorporation of high refractive particles having a refractive level above of that value. This lowest necessary level of refractive indices for the polyorganosiloxane (B) can suitably be met e.g. with 6 mol. % siloxy units substituted with appropriate optical dense groups R^3 , R^6 . The amount of reactive groups like R^2 and R^4 which can contribute to the creation of a network after a cure reaction are chosen to such an extent as determined by the desired mechanical properties of the cured article or coat; i.e. a rubber-like behavior needs fewer reactive groups than a resin-like article having a duromeric appearance. For a rubber-like appearance the reactive groups R^2 or those in R^4 should not exceed 20 mol.% of all siloxy groups.

The polyorganosiloxane (B), (B1) and (B2) formula (I) or (II) are selected from the group of polyorganosiloxanes (B) comprising symmetrical and asymmetrical substituted polyorganosiloxane (B) of formula (IIIa) to (IIIe)





$m = 1$ to 7

$p = 1$ to 9 ,

wherein

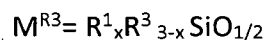
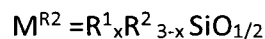
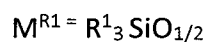
$u = 0$ to 500

$v = 0-50$ preferably $0-20$

$w = 0-500$ preferably $1-100$

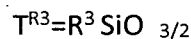
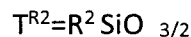
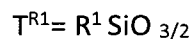


wherein M and M^* are selected from the group of M^{R1} , M^{R2} , M^{R3} ,

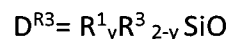
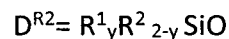
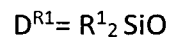


$x = 0$ to 2

T selected from T^{R1} , T^{R2} , T^{R3} ,



D is selected from D^{R1} , D^{R2} , D^{R3} ,



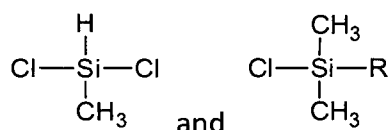
$y = 0$ to 1 ,

characterized in that at least one polyorganosiloxane (B) comprises more than 5 mol.% siloxy units which are substituted with R^{22} and R^{42} .

These structures may express that the substituents R^1 to R^3 can be placed at many different positions of the silicon atoms of the inventive polyorganosiloxanes (B), however there are some

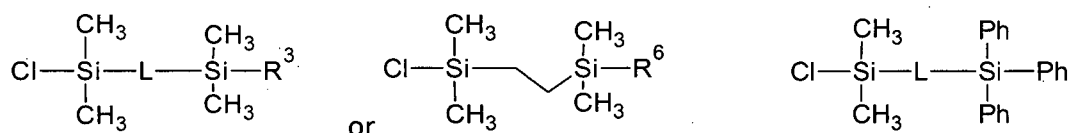
particularly desirable structural elements, which are easily accessible with the basic silanes of the industrial silicon chemistry.

Such structural elements use precursors starting from, *e.g.*,



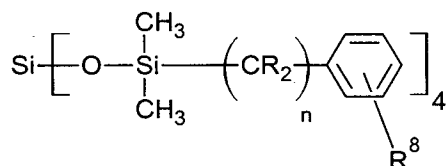
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R= R², R³, R⁴, R⁷



Ph = phenyl;

Examples for the -L-R³ may be shown by the following formula



10

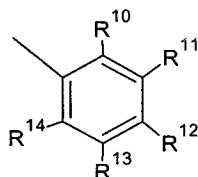
R⁸ is selected from the groups R¹⁰ to R¹⁴, for example

R¹⁰, R¹⁴ is hydrogen or R¹ and R¹¹, R¹², R¹³ are selected from -OR⁹, forming groups,

R⁶me₂Si-, wherein R⁶= C6-C10-aryl, C7-C12-arylalkyl, C6-C12-cycloalkyl, C7-C16-bicycloalkyl, C6-C12-cyclothioalkyl, C5-C12-hetereo-N, -O, -S-aryl, optionally substituted by R¹, OH, Cl, and a silyl ether group R¹³Si-O-,

15

and of unsubstituted or substituted oxyphenyl moieties, wherein the group

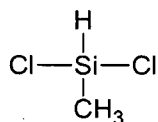


20

is substituted with R¹⁰ to R¹⁴,

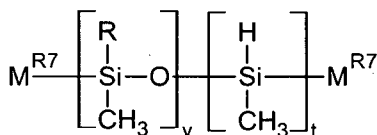
whereby at least one of the groups R¹¹ to R¹³ is an OH group, bonded via L to the silicon atom of the siloxy unit.

Another precursor can start from methyldichlorohydrogensilane:



In a next hydrosilylation step a compound with one or two unsaturated groups can be added.

If not all SiH groups are reacted in the hydrosilylation reaction the polyorganohydrogensiloxane is a molecule as defined under (B2) and can serve as crosslinker for a polymer (B1) which provides unsaturated groups.



$y = u, v, w,$

$\text{M}^{\text{R}^7} = \text{R}^1_x \text{R}^7_{3-x} \text{SiO}_{1/2} \text{ me}_3\text{SiO}_{1/2}, \text{Hme}_2\text{SiO}_{1/2}$

10 $x = 2 \text{ or } 3$

the indices $u, v, w,$ are as defined above

$t = 0 \text{ to } 100$

$\text{R} = \text{R}^2, \text{R}^3, \text{ and } \text{R}^4,$

$\text{M}-\text{D}^{\text{R}^1}_u-\text{D}^{\text{R}^3}_w-\text{D}^{\text{R}^2}_v-\text{D}^{\text{R}^7}_t-\text{M}$

15 $\text{D}^{\text{R}^7} = \text{HMeSiO}$

$\text{R}^3 \text{ is } -\text{L}-\text{R}^4$

One particularly suitable R^4 group is an alkoxysilyl substituent of the structure $(\text{R}^1\text{O})_x\text{R}^{1}_{3-x}\text{Si}-$ where x is 3.

The polyorganosiloxane (B) further comprises the unit L.

20 In addition to the aforementioned groups L, further suitable groups L are selected from

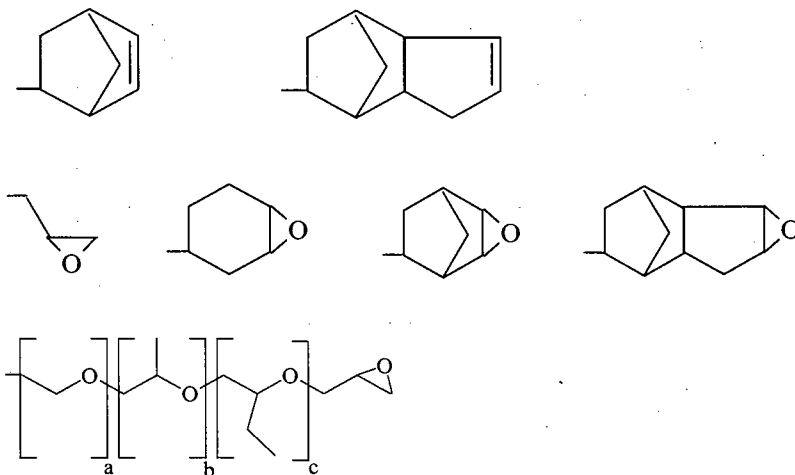
L1 and L2 which both are independently selected from the group which consists of a single bond, $-\text{CH}_2\text{CH}_2-$, $-\text{CH}_2\text{CH}_2\text{O}-$, $-\text{CH}_2\text{CH}_2\text{CH}_2\text{O}-$, $-\text{CH}(\text{CH}_3)\text{CH}_2\text{O}-$, $-\text{CH}=\text{CHCH}_2\text{O}-$, $-\text{CH}=\text{CHC}(\text{O})-$, and $-\text{C}(\text{CH}_2\text{O})=\text{CHCH}_2\text{O}-$;

25 Other examples for the group R^2 are

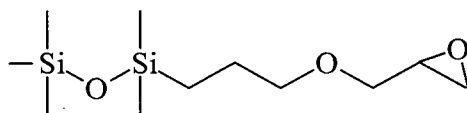
-CH=CH₂, -CH₂CH=CH₂, -(CH₂)₄CH=CH₂, -C(O)(CH₂)₈CH=CH₂, -CH₂C≡CH, -C(O)C≡CH, -(CH₂CH₂O)_a-
 (CH₂CH(CH₃))_b-(CH₂CH₂CH(CH₃))_c-OCH=CH₂, -(CH₂CH₂O)_a-(CH₂CH(CH₃))_b-(CH₂CH₂CH(CH₃))_c-
 OCH₂CH=CH₂, -[Si(CH₃)₂OSi(CH₃)₂]CH=CH₂;

with a, b, and c are independently 0 to 20, in one embodiment, 0 and 1 to 20, and a+b+c is 0 to
 5 20, in one embodiment 0, and in another embodiment 1 to 20,

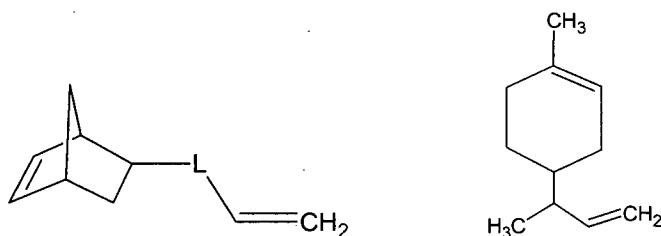
Examples for the group R²² where the alkylene group R² provides a higher optical density, i.e.
 higher refractive index, are

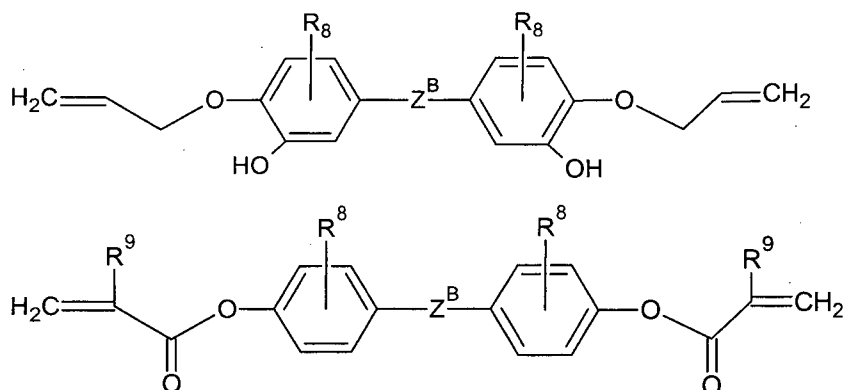


with a, b, c are independently 0 to 20, in one embodiment 0, and in another embodiment 1 to
 20, and a+b+c is 0 to 20, in one embodiment 0, and in another embodiment 1 to 20, or R⁶² is

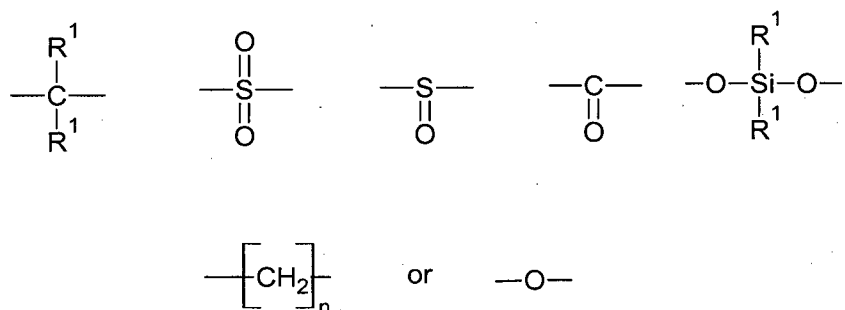


Suitable precursors for R²² can also be selected from





and Z^B is selected from the following groups:



5

R^3 is a group $-L-R^4$

Wherein R^4 comprises a group R^{42} i.e. a group R^4 having higher optical density which are selected from the group of R^{22} , C6-C22-cycloalkyl, C6-C12-cyclothioalkyl, C7-C22-bicycloalkyl, C6-C22-aryl, C5-C12-hetero-N, -O, -S-aryl, C8-C22-polycyclic aryl, C7-C22-alkylaryl, C7-C22-arylalkyl, C8-C22-arylalkylenearylalkyl, epoxides, of the group R^2 , R^{22} , and

10

$R^6_x R^{1_{3-x}} Si-$, wherein $x = 1-3$,

$R^6 =$ C6-C10-aryl, C7-C12-arylalkyl, C6-C12-cycloalkyl, C7-C16-bicycloalkyl, epoxy C3-C12-epoxy alkyl, C6-C12-cycloalkyl, epoxy C7-C16-bicycloalkyl, C6-C12-thiocycloalkyl, C5-C12-hetreo-N, -O, -S-aryl,

15

bonded via a single bond or carbon bond of L to the silicon atom of the siloxy unit,

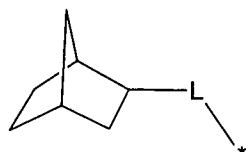
Preferred suitable groups R^{42} are

cumylphenoether, bisphenoethers, phenyl, biphenyl, naphthyl,, benzhydryl, cinnamyl, phenethyl; styryl, trityl, anthryl, phenanthryl, chrysyl, aryl substituted thiophene, thiadiazole, thianthrene, carbozole, 9-allylcarbazol, indol, phosphazenes, phosphonates and derivatives thereof;

5

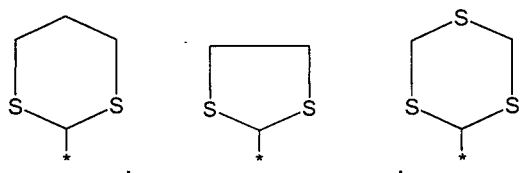
epoxides of R^2 and R^{22} such as C6-C22-epoxyalkyl, C6-C22-epoxycycloalkyl, C4-C12-dioxolane, C5-C12-thiophene, C3-C12-1,3-dithiolane, C3-C12-1,3,5-trithiane, C4-C2-1,3-dithiane, C5-C12-tetrahydro-2H-thiopyran

other examples for the group $-L-R^4$ or $-L-R^{42}$ are



10

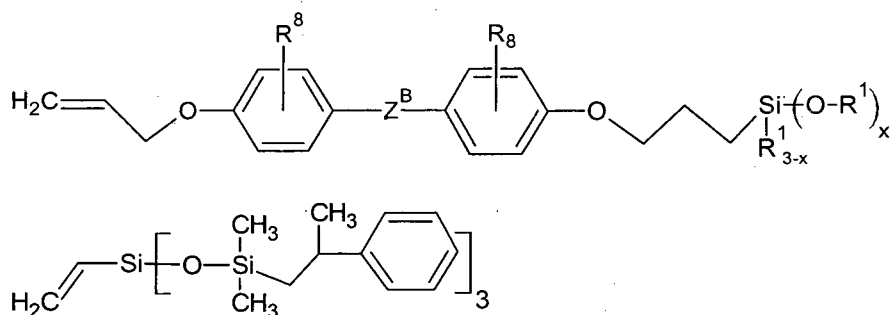
For example preferred groups R^{42} are at L are



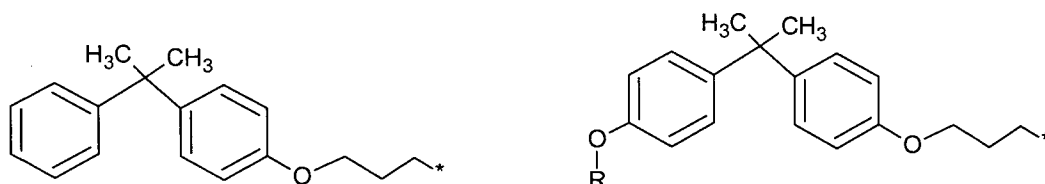
1,3-dithiane, 1,3-dithiolane, 1,3,5-trithiane or cumylphenol ether, bisphenoether derivatives.

15 Precursors for R^{42} can be

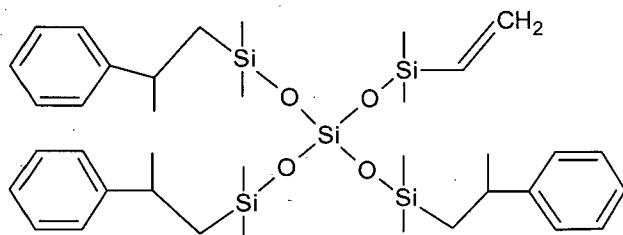
H-Siph₃, alkenyl-Siph₃, vinyl-Siph₃, alkenyl-Sime₂R⁶ N-vinyl-carbazol,



Examples for the groups for R^{42} after addition maybe trisorganosilyl, trisphenylsilyl, trimethylsilyl, phenylpropyldimethylsilyl, styryldimethylsilyl, vinyl dimethylsilyl, trisalkenylsilyl, trisvinylsilyl, vinyl dimethylsilyl



5



In one embodiment the polyorganosiloxane (B1) used in one of the examples has the structure $M-D^{R1}_u-D^{R3}_w-D^{R2}_v-M$

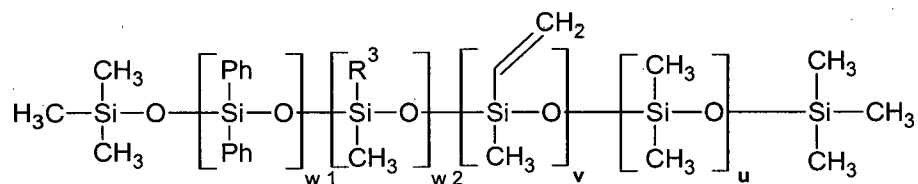
10 $D^{R1} = \text{me}_2\text{SiO}$

$D^{R2} = \text{vinylmeSiO}$

$D^{R3} = w1 = \text{Ph}_2\text{SiO}$ ph= phenyl and

$w2: (\text{ph}_3\text{-Si-C}_2\text{H}_4)\text{meSiO}$

15 Suitable structures for polyorganosiloxane (B1) include, but are not limited to,



$u=2$

$w = w_1 + w_2$, i.e., $w_1 = 2$; $w_2 = 3.6$

$v = 4.2$

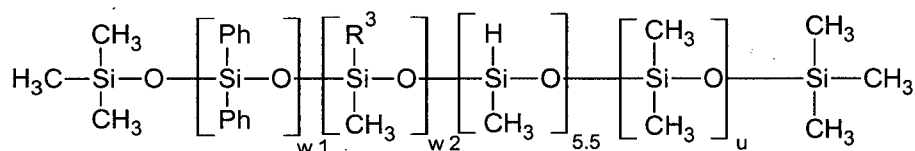
$R^3 = \text{Ph} = \text{phenyl}$ or $R^3 = -(\text{CH}_2)_2\text{-SiPh}_3$, SiPh_3

A molecule of this structure has the following properties $n_D^{20} = 1.555$ viscosity 100 Pa.s at 25°C

5

In one embodiment the polyorganosiloxane (B2) used in one of the examples has the structure

$\text{M-D}^{R^1}_u\text{-D}^{R^3}_w\text{-D}^{R^7}_t\text{-M}$ such as



10 $t = 5.5$

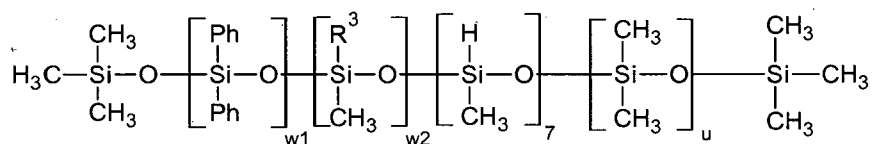
$u = 2$

$w = w_1 + w_2$ $w_1 = 2$, $w_2 = 3.5$

$\text{Ph} = \text{phenyl}$

$R^3 = -\text{C}_2\text{H}_4\text{-SiPh}_3$

15 Another molecule of (B2) has the following properties $n_D^{20} = 1.5504$ viscosity 18 Pa.s at 25°C



$u = 2$

$w = w_1 + w_2$ $w_1 = 2$, $w_2 = 4$

$\text{Ph} = \text{phenyl}$

20 $R^3 = \text{cumylphenol}$

This concrete molecule has the following properties $n_D^{20} = 1.5448$, viscosity 4.74 Pa.s at 25°C, 92.5 % transmission at 400 nm.

In another embodiment of the polyorganosiloxanes (B) used in the inventive composition, at least one of the polyorganosiloxanes (B) is selected from the group of formula $M^{R^2}-D^{R^1}_u-D^{R^2}_v-D^{R^3}_w-M^{R^2}$,

$[M_{0.4-4}Q]_{1-200}$,

$[M_{0.4-4} D_{1-10} Q]_{1-200}$,

$M_{2-10}D_{0-500}T_{1-10}$, and

$M_{2-10}D_{0-500}T_{1-10}$, wherein

the M and M* are units are selected from the group of $M^{R^1}, M^{R^2}, M^{R^3}$,

the D units are selected from $D^{R^1}, D^{R^2}, D^{R^3}$,

the T units are selected from $T^{R^1}T^{R^2}, T^{R^3}$

whereby R^1 = methyl, 3,3,3-trifluoropropyl

$u = 0$ to 200

$v = 0$ -20

$w = 1$ to 200, and

$R^4 - \{-L[SiR_2O]_p-SiR_2\}_m-L-R^{4*}$,

R^2 is selected from vinyl, allyl, hexenyl, octenyl, R^{22} selected from cyclohexenylethyl, limonyl, norbornenyl, norbornenethyl, vinylphenylethyl, C2-C8-alkenylphenylether, C2-C8-alkenylbiphenylether, allyloxyphenyloxypropyl

$R^3 = -L-R^4$, wherein,

L is a single bond, a divalent C1 to C8-alkylene groups, which can be interrupted by one or more O, - or N -C(O)-, and/or -NR⁹- moieties, and substituted by one or more OH groups,

R^4 = which is selected from the group of R^1, R^2, R^{22} , hydrogen,

$(R^1X)_xR^{13-x}Si-$, wherein $x = 1-3$, $X =$ C1-C8 alkoxy, C1-C8-alkylcarboxy, C1-C8-alkylamino,

and an ionic group derived from esters of carboxylic acids, S or P acids such as

$R^9-C(O)-O-$, $(R^9-O)_2-P(O)-O-$, $(R^9-O)_2-P(O)-$, $(R^9-O)_2-P-O-$, $-NHR^9-CH_2-COOH$,
 $-NHR^9-CH_2-O-S(O)_2(OH)$, $-S-S(O)_2(OH)_2$, wherein R^9 is= hydrogen, C1-C8 alkyl, C2-
 C8 alkenyl, me_3Si- ,

and acid salts of amines, phosphines or preferably salts having quaternary $-N^+R_3$
 or $-P^+R_3$ groups, and R^{44} selected from R^{42}

cyclohexyl, norbornyl, phenyl, phenylpropyl, phenylethyl, substituted
 hydroxyphenyl, eugenol, cumylphenoether, bisphenoethers, naphthyl, C5-C12-
 thiophene, C8-C12-indol, C12-C22-carbazol, C4-C12-dioxolane, C5-C12-
 thiophene, C3-C12-1,3-dithiolane, C3-C12-1,3,5-trithiane, C4-C2-1,3-dithiane, C5-
 C12-tetrahydro-2H-thiopyran, C6-C12-epoxyalkyl, C6-C22-epoxycycloalkyl,
 optionally substituted or interrupted by R^1 , OH, Cl, F, $-NR^9-$, $-O-$ $-S-$ atoms,
 substituted with $-OR_9$,

and

$R^6_xR^{13-x}Si-$, wherein $x= 1-3$;

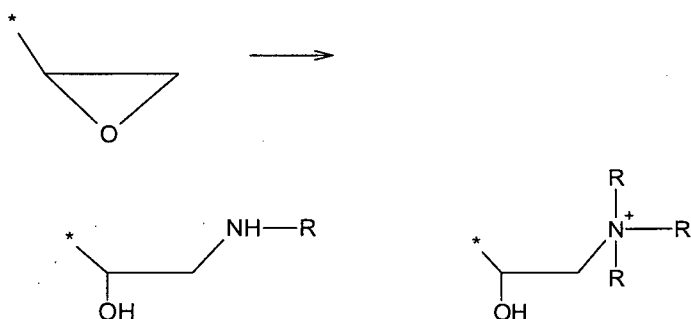
$R^6=$ C6-C10-aryl, C7-C12-arylalkyl, C6-C12-cycloalkyl, C7-C16-bicycloalkyl, epoxy
 C3-C12-epoxy alkyl, C6-C12-cycloalkyl, epoxy C7-C16-bicycloalkyl,
 C6-C12-thiocycloalkyl, C5-C12-hetereo N, O, S-aryl, bonded via L to the silicon
 atom of the siloxy unit, whereby at least one component (B) comprises more
 than 10 mol.% siloxy units which are substituted with R^{22} and R^{42} .

The group R^4 or R^{4*} can also be selected from an ionic group. These ionic groups R^4 can be
 synthesized on different routes.

One of the exemplary ionic groups is derived from alkylation reaction, *i.e.*, hereby an
 alkylhalogenide or halogenalkylene group is reacted with an amine or phosphine to result
 ammonium groups either hydrogen addition acid salts or preferably quaternary $-N^+R_3$ or $-P^+R_3$
 groups.

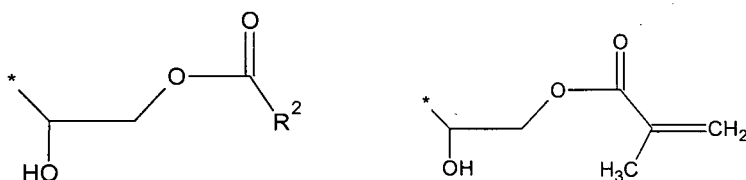
Another synthesis route can start with epoxy groups which are reacted with amines,
 phosphines, carboxylic acid or inorganic acids or half esters of P or S based acids.

In that embodiment an oxiranyl group is used as alkylation agent and is reacted with a primary, secondary or tertiary amine to form a ring opened hydroxyl amine or ammonium unit as group R4.



In another example, the oxiranyl group is reacted with a carboxylic acid or any other acid, *e.g.* a methacrylic acid, a phosphoric acid, *etc.* to form ester groups inserting a new R group, which preferably an unsaturated group R².

Such a reaction allows changing the character of R4 group into a R2 group.



In one exemplary embodiment, the composition of the invention comprises at least one of the polyorganosiloxanes (B) which is selected from the group of formula $M^{R^3}-D^{R^1}_u-D^{R^2}_v-D^{R^3}_w-M^{R^3}$

whereby R¹ = methyl, 3,3,3-trifluoropropyl

u= 0 to 100

v= 0-10

w= 1 to 100 and

R² is selected from vinyl, allyl, hexenyl, octenyl, R²² selected from cyclohexenylethyl, limonyl, norbornenylethyl, vinylphenylethyl, C2-C8-alkenylphenylether, C2-C8-alkenylbiphenylether, allyloxyphenyloxypropyl

R³= -L-R⁴,

and L is defined above

R^4 is selected from the group of $(R^1X)_xR^{13-x}Si-$, wherein $x = 1-3$, $X =$ C1-C8 alkoxy, C1-C8-alkylcarboxy, C1-C8-alkylamino,

and an ionic group derived from esters of carboxylic acids, S or P acids such as

$R^9-C(O)-O-$, $(R^9-O)_2-P(O)-O-$, $(R^9-O)_2-P(O)-$, $(R^9-O)_2-P-O-$, $-NHR^9-CH_2-COOH$,

$-NHR^9-CH_2-O-S(O)_2(OH)$, $-S-S(O)_2(OH)_2$, quaternary $-N^+R^9_3$,

and

$R^{42} =$ cyclohexylethyl, norbornyl, norbornylethyl, phenyl, phenylethyl,

phenylpropyl, naphthyl, eugenol, bisphenolethers, cumylphenolether,

glycidylpropylether, epoxylimonyl, epoxycyclohexanethyl, epoxynorbornyl, 1,3-

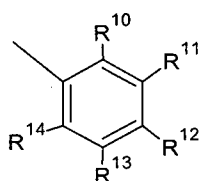
dithiolane, 1,3,5-trithiane, 1,3-dithiane, thiophenyl tetrahydro-2H-thiopyranyl,

carbazol, indol, trisphenylsilyl, and

R^6me_2Si- , wherein $R^6 =$ C6-C10-aryl, C7-C12-arylalkyl, C6-C12-cycloalkyl, C7-C16-bicycloalkyl, C6-C12-cyclothioalkyl, C5-C12-hetreo-N, -O, -S-aryl, optionally

substituted by R^1 , OH, Cl, and a silyl ether group R^1_3Si-O- ,

and of unsubstituted or substituted oxyphenyl moieties, whereby the group



is substituted with R^{10} to R^{14} ,

wherein R^{10} , R^{14} is hydrogen or R^1 and

R^{11} , R^{12} , R^{13} are selected from $-OR^9$,

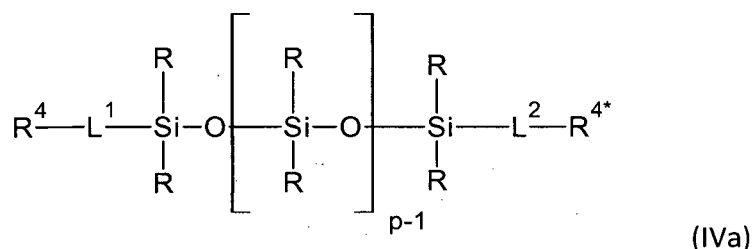
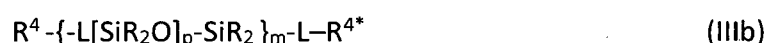
Whereby at least one of the groups R^{11} to R^{13} is a OH group,

bonded via L to the silicon atom of the siloxy unit,

whereby at least one component (B) comprises more than 10 mol.% siloxy units which are substituted with R^{22} and R^{42} .

The composition of the invention comprises at least one polyorganosiloxanes (B) with a very specific structure of the polyorganosiloxane (B) which provides the best performance in the stabilization of the component (A) the metal oxide/hydroxide. This polyorganosiloxane (B)

5 has the structure selected from the group of the formulas (IIIa), (IIIb), and (IVa)



10 R, R* can be different and are selected from the group which consists of R¹, R², R²², R³, R⁴, R⁴² as defined above,

wherein the terminal groups R⁴ and R^{4*} are selected from R⁴ and R⁴² defined above but are different to each other,

p = 1 or 4 or 9

15 R¹ = methyl,

R³ = -L-R⁴

whereby L is selected from L1 and L2 are divalent C1 to C8-alkylene groups, which can be interrupted by one or more O, - or N -C(O)-, and/or -NR⁹- moieties, and substituted by one or more OH groups,

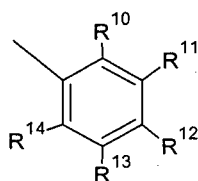
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R² is selected from the group which consists of vinyl, hexenyl, octenyl, R²² = limonyl, cyclohexenylethyl, vinylphenylethyl, C2-C8-alkenylphenylether, C2-C8-alkenylbiphenylether allyloxyphenyloxypropyl,

R⁴ is and (R¹X)_xR¹_{3-x}Si-, wherein x = 1-3, X = C1-C8 alkoxy, C1-C8-alkylcarboxy, C1-C8-alkylamino,

25 and

selected from the group R^{42} which consists of R^{22} , phenyl, phenylethyl, phenylpropyl, naphthyl, eugenol, bisphenoethers, cumylphenoether, norbornyl, glycidylpropylether, cyclohexenoxide ethyl, limonyloxide, norbornyloxide, 1,3-dithiandimethylsilyl, trisphenylsilyl, $R^6\text{me}_2\text{Si-}$, wherein $R^6 =$ phenylethyl, phenylpropyl, eugenol, limonyl, epoxylimonyl, glycidylpropylether
 5 epoxycyclohexylethyl, norbornenylethyl, epoxy norbornenylethyl, carbazol, indol, and of unsubstituted or substituted oxyphenyl moieties, whereby the group



10 is substituted with R^{10} to R^{14} ,

wherein R^{10} , R^{14} is hydrogen or R^1 and R^{11} , R^{12} , R^{13} are selected from $-\text{OR}^9$,

wherein at least two of the groups R^{11} to R^{13} are an OH group,

15 bonded via L to the silicon atom of the siloxy unit, whereby at least one component (B) comprises more than 10 mol.% siloxy units which are substituted with R^{22} and R^{42} .

The asymmetrically substituted polyorganosiloxane (B) comprises two different terminal groups. Such polyorganosiloxanes (B) having two different terminal substituents are synthesized
 20 stepwise by at least a in two step process.

Both reactions steps include preferably a hydrosilylation reaction, whereby either unsaturated compounds or compounds comprising SiH groups providing the group R^4 or R^{42} which are reacted with alpha, omega functional organodi-, organopenta- or organodecasiloxanes providing the complementary group for a hydrosilylation addition reaction.

25 In embodiments, it is desirable to use pentaorganosiloxanes as precursor. Such organopentasiloxanes having exactly five siloxy units in an amount of more than 85 wt.% are reaction products of a non-equilibrating ring-opening reaction of hexaorganotrisiloxane (JP 11-158188 A). These precursors can be synthesized in very high purity. These polyorganosiloxanes

are therefore called monomodal polyorganosiloxanes due to its uniform narrow distribution of chain lengths.

Based on these specific uniform polyorganosiloxane as precursors having a small index of the polydispersity, *i.e.*, weight-average molecular weight to the number-average molecular weight M_w/M_n is in the range 1 to 1.2, the new asymmetric polyorganosiloxanes were synthesized which are suitable for the purpose of the invention. The organodi- and organopenta- or decasiloxane precursors can be purified *e.g.* by distillation up to a content of more than 90 wt.%. The inventors found a way to insert the different terminal groups stepwise, whereby after each reaction step a purification step could be applied, which allows to control the completeness of the addition of the first terminal end group and then the addition of a second different terminal group.

These precursors can be submitted immediately to addition reaction with compounds providing the group R^4 or submitted to chain extension reaction. The chain extension is another option in which more than one polyorganosiloxane showing to more than 85 wt.% only one chain length are linked to each other by the group L. Hereby the monomodal organodisiloxane, organopentasiloxane or organodecasiloxane, which are symmetrically substituted with reactive groups, are reacted with two other monomodal siloxane blocks and then after purification with the next two blocks in order to synthesize a block polymer with distinct well defined monomodal polysiloxane blocks.

For example, applying the reaction steps

a1) first compound $Z^*-L-[SiR_2O]_p-SiR_2-L-Z^*$

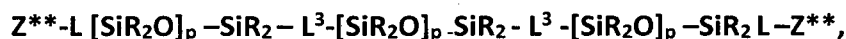
with 2 mols of a α,ω -terminated polyorganosiloxane of the formula

$Z^{**}-L-[SiR_2O]_p-SiR_2-L-Z^{**}$

Z^* is selected from SiH-silane or siloxane, alkenyl, Cl-alkyl or Br-alkyl, epoxy, amine, -NCO

Z**selected from Z* which can complementarily react with each other optionally in the presence of a catalyst, wherein p=1 or 4 or 9, R, L=L1, L2 or L* are defined above,

whereby Z* and Z** in step a1) are forming a unit $-L^3-$,

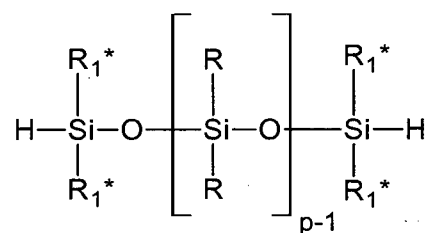


wherein Z** is R², R²², R⁴, R^{4*}, R⁴², R^{42*}.

In the final step, the precursors carrying the groups Z* and Z**=R⁴ or R^{4*} are with a Z* group of the intermediate to form another L group in order complete the final polyorganosiloxane (B) which is asymmetrically substituted at the terminal groups Z**=R⁴, R⁴² or R^{4*}, R^{42*}.

The preferred precursors for the asymmetrically substituted polyorganosiloxane (B) are organodi-, organopentasiloxane and organodecasiloxane either with alpha, omega dihydrogen or alpha, omega di-alkenyl substituents.

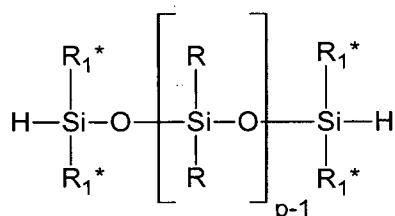
In a first embodiment of the synthesis for the asymmetrically substituted polyorganosiloxane (B) an alkenyl compound forming after reaction R⁴ is added to the starting precursor of Formula (IVb)



(IVb)

whereby a first unsaturated compound providing the group R⁴ or R⁴² and a different second unsaturated compound providing the group R^{4*} or R^{42*} is added to that alpha, omega-dihydrogendisiloxane, -pentasiloxane or -decasiloxane.

For example without being exhaustive it is preferred to use the following pentasiloxanes as precursor for the asymmetrically substituted polyorganosiloxanes of the invention.



R_1^* = methyl, phenyl, 3,3,3-trifluoropropyl

R selected from R_1 = methyl, R^4 = phenyl, styryl, phenylpropyl, etc.

$p = 1$ or 4 or 9.

5

For example in such first addition reaction the alkenyl precursor may be an alkoxysilane of the formula $(\text{R}^1\text{O})_x\text{R}^{1-3-x}\text{Si}-\text{CH}=\text{CH}_2$ to form a group R^4 ,

$x = 1-3$ to form $(\text{R}^1\text{O})_x\text{R}^{1-3-x}\text{Si}-\text{CH}_2\text{CH}_2-\text{SiR}_2-\text{O}-[\text{D}]_{p-1}-\text{SiR}_2-\text{H}$.

The reaction is catalyzed with usual hydrosilylation catalysts, such as, *e.g.*, a Pt-Karstedt catalyst or other suitable Pt catalysts.

10

The intermediate product after the first addition reaction must be purified by an appropriate way to obtain an organodisiloxane, a organopentasiloxane or a organodecasiloxane with two different groups R^4 or R^{4*} after the second addition reaction.

By a more detail description the reaction is carried out in a way whereby a molar excess of the SiH functionalized organodi- or pentasiloxane is reacted with an unsaturated silane, *e.g.*, having the structure $(\text{R}^1\text{O})_x\text{R}^{1-3-x}\text{Si}-\text{CH}=\text{CH}_2$ wherein x is 1-3 in the presence of a hydrosilylation catalyst. Typically, the excess of the SiH precursor according to formula (IVc) can be removed by distillation.

15

In a second hydrosilylation step the intermediate of the formula

20

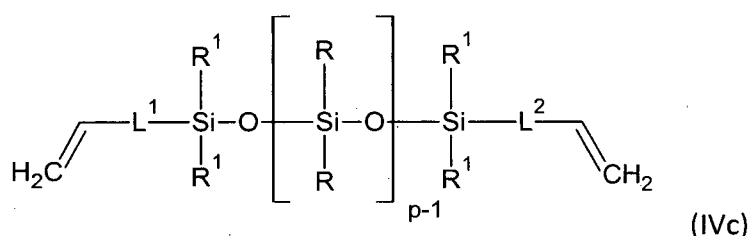
$(\text{R}^1\text{O})_x\text{R}^{1-3-x}\text{Si}-\text{CH}_2\text{CH}_2-\text{SiR}_2-\text{O}-[\text{D}]_{p-1}-\text{SiR}_2-\text{H}$

having the desired first reactive group R^4 , *i.e.* the alkoxysilyl group, is reacted with a second compound comprising at least one unsaturated group to yield the desired final asymmetric polyorganosiloxane. Examples of suitable groups for the second addition reaction include, but are not limited to this enumeration, bis-olefinic compounds, 1,5-hexadiene, norbornadiene, 5-ethylidene-2-norbornene, limonene, exo-dicyclopentadiene, ethylene glycol diallyl ether,

25

propylene glycol diallyl ether, divinyl-tetramethyldisiloxane, divinylbenzene, diallylphenyl ether, trisphenylvinylsilane, N-vinylcarbazol, *etc.*; acetylenic-olefinic, *e.g.*, propargylic alcohol-undecylenic acid ester, *etc.*, acetylenic-bis-olefinic, *etc.*; 1,4-butyndiole-bis(undecylenic acid) ester, and bis-acetylenic, *e.g.*, bis-propargyl ether

- 5 In a second embodiment of the synthesis of the asymmetrically substituted polyorganosiloxane (B) a complementary synthesis route is starting with an alpha, omega-dialkenyl di-, pentasiloxane or decasiloxane.



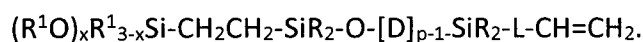
R^1 = methyl, phenyl,

- 10 R selected from R^1 = methyl, R^4 =phenyl, styryl, phenylpropyl, *etc.*

$p = 1$ or 4 or 9.

whereby a first and a second compound providing the group R^4 having a SiH group is added stepwise to that alpha, omega-dialkenyl di-, pentasiloxane or decasiloxane to obtain a di-, organopentasiloxane or organodecasiloxane which has two different terminal groups R^4 respectively R^{42} .

For example a preferred suitable route for the incorporation of alkoxysilyl groups and olefinic groups into the polyorganosiloxane compound is the addition of alkoxysilanes of the structure $(\text{R}^1\text{O})_x\text{R}^{13-x}\text{Si}-\text{H}$ to form a group R^4 , wherein x is 1-3, in an amount of less than 1 mol /1 mol dialkenylpentasiloxane of formula (IVc) in the presence of a hydrosilylation catalyst yielding the target derivatives of the structure



Typically, the excess of the dialkenyl di- or pentaorganosiloxanes can be removed by distillation. This product can already be used as such as asymmetrical polyorganosiloxane (B), if the second assumption for the inventive component (B) is fulfilled, i.e. some of the groups R must be

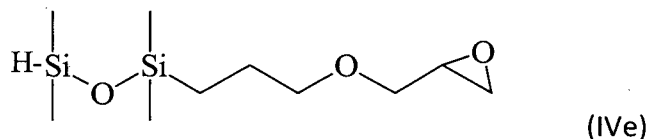
chosen from optical dense substituents R^{22} or R^{42} and a sufficient concentration of these substituents in order to obtain a refractive index n_D^{20} of more than 1.43.

In a further reaction step a SiH group providing a different group R^4 can be added.

Such a precursor moiety can again also be another di or organopentasiloxane in order to enlarge the number of siloxane blocks.

For example the precursor of the formula

$(R^1O)_xR^{13-x}Si-CH_2CH_2-SiR_2-O-[D]_{p-1}-SiR_2-L-CH=CH_2$ is *e.g.* can be further reacted with a silane or a siloxane compounds comprising L^*-R^4 having in addition one SiH-group and a second reactive group R^4 which *e.g.* is an epoxy group and be counted as R^{42} , for example of formula (IVe),



in the presence of a hydrosilylation catalyst.

It is in the scope of the invention to change the order of the addition steps for the compounds comprising $-L^*-R^4$. For example, it is possible to react the divinyl-di- or -pentaorganosiloxane compound with the compound of the type SiH-epoxysiloxane first and then afterwards with a silane of the structure $(R^1O)_xR^{13-x}Si-H$ wherein x is 1 -3.

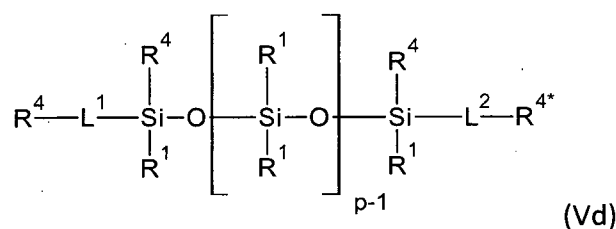
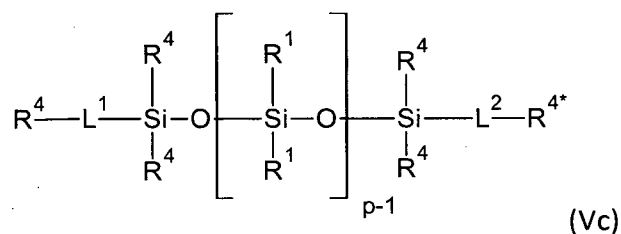
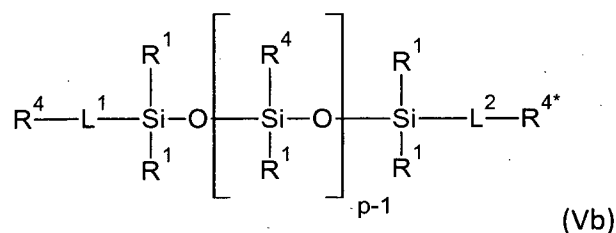
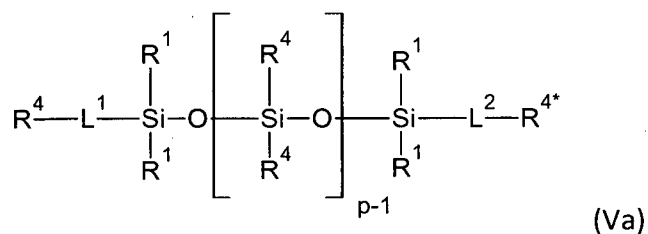
Particularly suitable structures of the polyorganosiloxane (B) are linear polyorganosiloxanes which are substituted with different terminal groups R^4 or R^{42} and R^{4*} or R^{42*} selected from R^4 .

The siloxane block has either 2, 5 or 10 siloxy units. Polyorganosiloxanes with pentasiloxane units are particularly suitable in the inventive compositions.

Such polyorganosiloxanes (B) used in the inventive composition are defined as follows:

The polyorganosiloxane (B) is selected from the formula $M^{R3}-D^{R1}_u-D^{R3}_w-M^{R3*}$

wherein R^3 , R^{3*} are $-L-R^4$ or $-L-R^{4*}$ and the groups R^4 and R^{4*} selected from R^4 and R^{42} and are different to each other and whereby the polyorganosiloxane (B) is selected from group of the structural formulas



R^1 = methyl,

R^4 and R^{4*} as defined above,

$p = 1, 4$ or 9 , preferably 4

L^1 and L^2 are selected from the group L as defined above,

whereby L^1 and L^2 are divalent C1 to C8-alkylene groups, which can be interrupted by one or more O, - or N-C(O)-, and/or $-NR^9$ - moieties, and substituted by one or more OH groups,

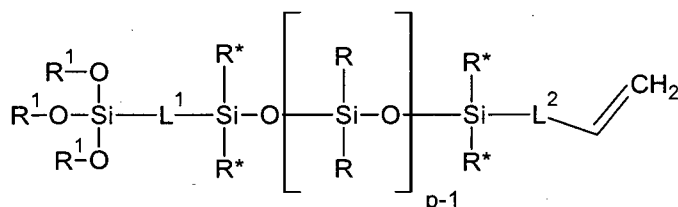
characterized in that (B) comprises more than 10 mol.% siloxy units which are substituted with groups selected from R²² and R⁴².

In one embodiment, when R^4 is $(R^1X)_xR^{1-3-x}Si-$ then R^{4*} is chosen from $-(C_2H_4O)_{1-6}(C_3H_6O)_{1-6}-R^3$ or; $-(C_2H_4O)_{1-20}(C_3H_6O)_{1-6}-OH$; $-(C_2H_4O)_{1-20}(C_3H_6O)_{1-6}-O-C1-C4$ alkyl; $-(C_2H_4O)_{1-20}(C_3H_6O)_{1-6}-O-C(O)-C1-C4$ alkyl.

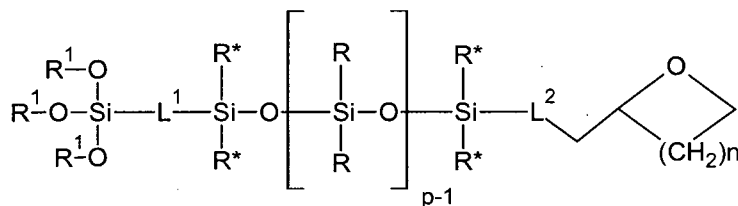
In an exemplary embodiment the asymmetric siloxane comprises more than 95 wt.% of a pentasiloxane or decasiloxane block showing only traces of siloxanes having less and more siloxane units than 5 or 10, so to say a monomodule chain distribution of $M_w/M_n < 1.1$. In another exemplary embodiment, the more pentasiloxane units are linked together via a sequence of small siloxane block units linked by a L3 unit having either 2 or 5 or 5+2+5 siloxane units, whereby all siloxane units are discrete molecules without chain length distribution.

In one exemplary embodiment of the composition, it contains at least one of the exemplary polyorganosiloxanes (B) suitable for making stable compositions according to the inventive. This polyorganosiloxane (B) is selected from the polyorganosiloxanes of the structure of formulas (VIa) to (VI f).

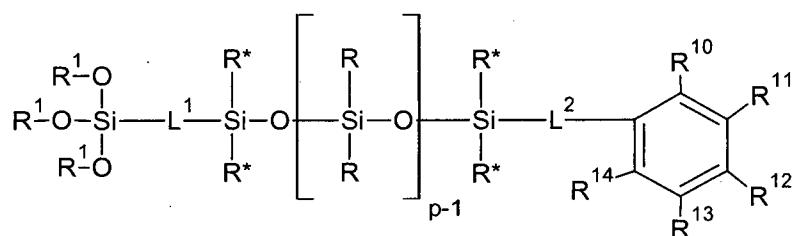
wherein R and R* are selected from R¹ and R⁴ whereby R and R* can be different



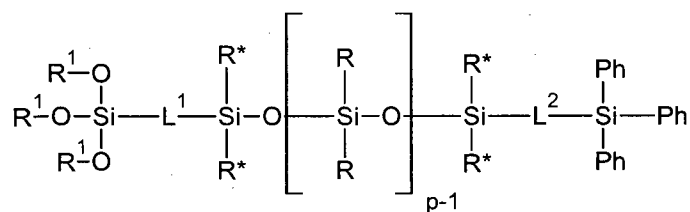
(VIa)



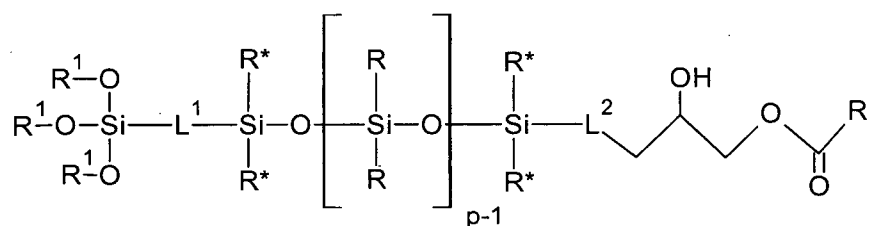
(Vlb)



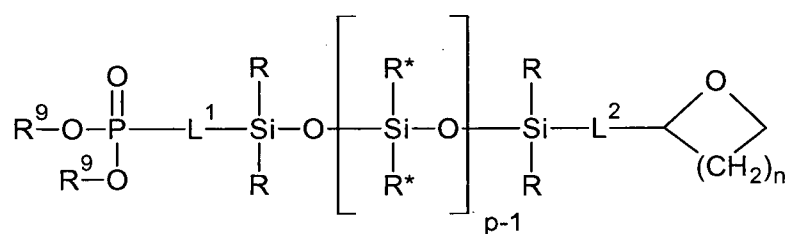
(Vlc)



(Vld)



(Vle)



(Vlf)

R, R* = methyl, 3,3,3-fluoropropyl, R⁴, R⁴²,

p = 1 or 4 or 9

n = 0-6

R^2 is selected from the group which consists of vinyl, hexenyl R^{22} = limonyl, cyclohexenylethyl, norbornenylethyl, vinylphenylethyl, C2-C8-alkenylphenylether, C2-C8-alkenylbiphenylether, allyloxyphenyloxypropyl

$R^3 = -L-R^4$

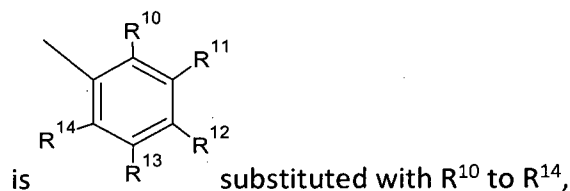
wherein L is selected from L1 and L2 are divalent C1 to C8-alkylene groups, which can be interrupted by one or more O, - or N -C(O)-, and/or $-NR^9$ - moieties, and substituted by one or more OH groups,

R^4 is and $(R^1X)_xR^{13-x}Si-$, wherein $x = 1-3$, $X =$ C1-C8 alkoxy, C1-C8-alkylcarboxy, C1-C8-alkylamino, and

selected from the group R^{42} which consists of phenyl, phenylethyl, phenylpropyl, naphthyl, eugenol, bisphenoethers, cumylphenoether, R^{22} which consists of norbornyl, glycidylpropylether, cyclohexenoxide ethyl, limonyloxide, norbornyloxide, 1,3-dithian-dimethylsilyl, trisphenylsilyl,

R^6me_2Si- , wherein $R^6 =$ phenylethyl, phenylpropyl, eugenol, limonyl, epoxyliomonyl, glycidylpropylether epoxycyclohexylethyl, norbornenylethyl, epoxy norbornenylethyl, carbazol, indol,

of unsubstituted or substituted oxyphenyl moieties, whereby the group



wherein R^{10} , R^{14} is hydrogen or R^1 and

R^{11} , R^{12} , R^{13} are selected from $-O-R^9$,

whereby at least two of the groups R^{11} to R^{13} are OH,

bonded via L to the silicon atom of the siloxy unit, whereby at least one component (B) comprises more than 10 mol.% siloxy units which are substituted with R^{22} and R^{42} .

These short chain polyorganosiloxanes provide in particular the ability to stabilize the metal oxide/hydroxide particles, since these polyorganosiloxanes have at least one functional terminal group which has the tendency to interact with the filler surface of the metal oxide/hydroxide particles and can adhere the polyorganosiloxane (B) to surface of the filler.

5 The second terminal group is more or less inert towards the filler surface or has a weaker interaction to the filler surface and can support shielding and separation of the particles from each other and block agglomeration. This second substituent R^4 can be selected from reactive groups R^4 , which in addition if desired can undergo crosslinking reactions with other reactive groups R^2 , R^4 or R^7 . The group R^4 can be selected also from the group R^{42} . The group R^{42} provides
10 in addition a higher optical density, i.e. is showing a higher refractive index not only as precursor but also when linked to the siloxane and is therefore is useful for making high refractive polyorganosiloxane in particular high refractive polyorganosiloxanes according to the invention. In one embodiment of the invention the composition comprises therefore at least two polyorganosiloxanes (B) wherein one is a polyorganosiloxane (B) asymmetrically substituted by
15 the terminal groups R^3 and R^{3*} respectively $-L-R^4$ and $-L-R^{4*}$, whereby the two substituents R^3 and R^{3*} at terminal ends are different.

In one exemplary embodiment of the invention, the composition comprises further at least a third polyorganosiloxanes (B2) which has an additional group R^7 , whereby R^7 is hydrogen in SiH group and can serve as crosslinker component (C).

20 In an exemplary embodiment, the asymmetric siloxane provides at least one group which can undergo curing reaction at least towards an additional polymer moiety used as binder or matrix polymer for the metal oxide/hydroxide filler (A) and a second group which can undergo interaction or reaction with the metal oxide/hydroxide component (A).

25 In one aspect of the invention, the present subject matter provides a silicone composition comprising:

- (a) at least one curable or uncureable polyorganosiloxane (B) comprising an polyorganosiloxane (B) asymmetrically substituted at the terminal siloxy groups used as binder matrix and/or dispersing polymer, and

(b) the metal oxide particles (A) of the invention.

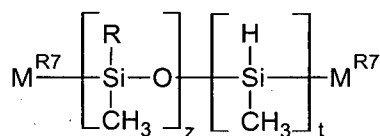
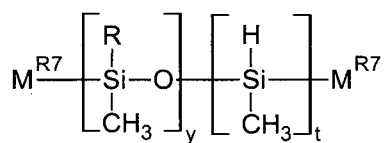
A preferred asymmetric polyorganosiloxane (B) is selected from siloxanes having at least one siloxane block with narrow distribution of the molecular weight, *e.g.* one siloxane block comprising more than 95 wt.% of a discrete organodi-, organopentasiloxane or organodecasiloxane.

In one aspect of the invention, the present subject matter provides a method for forming a curable polyorganosiloxane composition comprising reacting a polyorganosiloxane (B) in the presence of a metal oxide/hydroxide particles (A) and a crosslinker component (C) and optionally a catalyst component (D) by a curing reaction which is initiated by a hydrosilylation catalyst and in addition assisted either by heat or light, polycondensation, or radical polymerization or cationic polymerization by related catalysts or initiators.

The crosslinker component (C) can be selected from the group which consists of silanes and siloxanes having reactive groups towards the reactive groups of component (B1) or (B2), whereby these reactive substituents of the crosslinker component (C) are selected from the group which consists of SiH, alkenyl, alkoxy, amino, carboxy, epoxy, and thiol groups. Polyorganosiloxanes (B2) suitable as crosslinker in a hydrosilylation reaction comprise preferably at least two SiH units. The amount of the crosslinker component (C) to be used depends on the concentration of the unsaturated groups R^2 or R^{22} in the polyorganosiloxane (B1) and the SiH concentration in (B2). The range of the molar ratio of SiH: R^2 or R^{22} in the polyorganosiloxane (B1) can be in the range of about 0.1 to 7:1.

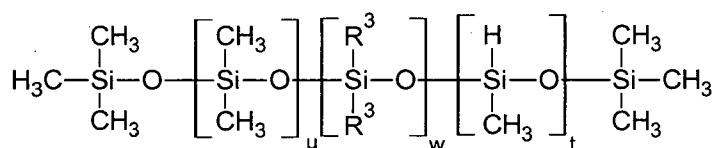
For smaller concentrations of unsaturated groups R^2 or R^{22} up to 10 mol.% R^2 or R^{22} related to all siloxy units a range of 0.5 to 4:1 is preferred, for higher concentrations of R^2/R^{22} , *i.e.*, > 10 mol.% of unsaturated groups the SiH: alkenyl R^2/R^{22} ratio is preferably 0.1 to 1:1.

Typical structures for polyorganosiloxanes (B2) suitable as crosslinker are di- or multifunctional SiH siloxanes:

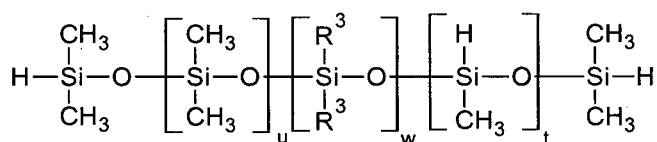


$z = u, v, \text{ or } w$

One specific example used in the examples may be $M\text{-D}_2\text{-D}^{\text{Ph}_2}\text{D}^{\text{H}_2}\text{-M}$



(VIIa)



(VIIb)

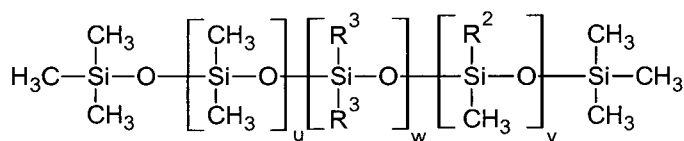
$u = 0 \text{ to } 100$, preferably $0 \text{ to } 10$

$w = 0 \text{ to } 100$, preferably $2 \text{ to } 10$

$t = 0 \text{ to } 60$, preferably $1 \text{ to } 10$ at least 2 SiH in a formula (VIIb)

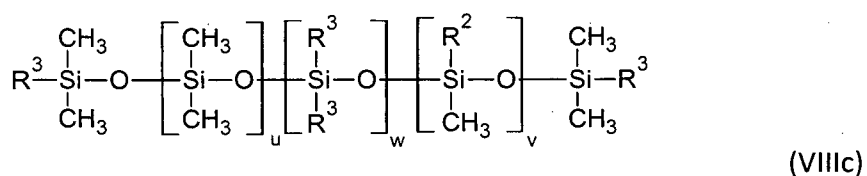
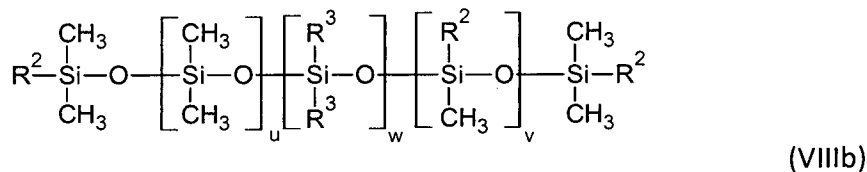
- 10 $\text{R}^3 = \text{L-R}^4$ as defined above, R^4 are preferably phenyl, phenylpropyl, eugenol, styryl(phenylethyl), trisphenylsilylethyl, limonyl, norbornylethyl, epoxylimonyl, glycidyoxypropyl, epoxycyclohexylethyl.

The invention includes a composition comprising at least one polyorganosiloxane (B) which
 15 comprises 5 mol.% of siloxy groups substituted by the optical dense group R^{22} or $\text{R}^3 = \text{-L-R}^{42}$.



(VIIIa)

one specific example used in the examples may be $M-D_2-D^{Ph}_2D^{Vi}_2M$



$u = 0$ to 500, preferably 0 to 200

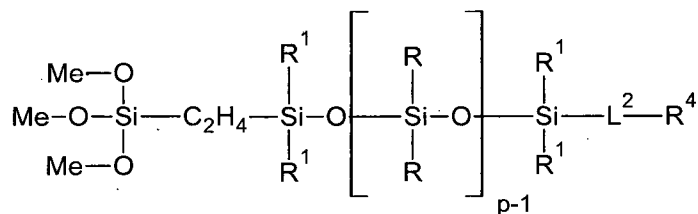
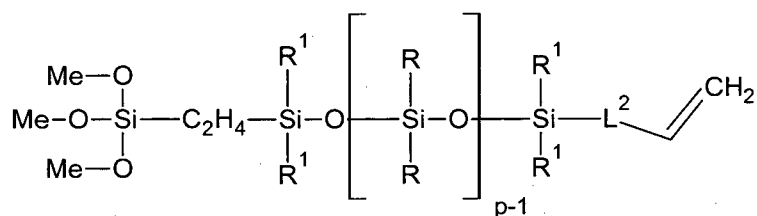
5 $w = 0$ to 400, preferably 2 to 150

$v = 0$ to 20, preferably 1 to 5,

wherein R^3 is as defined above, is preferably phenyl, phenylpropyl, eugenol, styryl(phenylethyl), trisphenylsilylethyl, limonyl, norbornylethyl, epoxylimonyl, glycidyloxypropyl, epoxycyclohexylethyl.

10

In one exemplary composition of the invention at least one polyorganosiloxane (B) comprises more than 20 mol.% of the siloxy groups are substituted with the optical dense groups R^{22} or R^{42} .



15

$R = R^1$ or R^3

$p = 1, 4$ or 9

$L^2 =$ single bond or C1-C22-alkyl, C7-C12-alkylarylen, C7-C12-alkylarylalylene

R4 as defined above.

In one preferred embodiment the composition of the invention comprises at least one polyorganosiloxanes (B) which is selected from group of the formula (IIIb)



L, R⁴ are as defined before; R⁴ and R^{4*} are selected from R and are different

R is selected from R¹, and R³,

p=1 or 4 or 9

m= 1 to 7.

- 10 This type of polyorganosiloxanes (B1) is based on asymmetrically substituted precursors for polyorganosiloxanes (B1), whereby the final addition of substituents creating the asymmetrical final polyorganosiloxanes (B1) is preferably a hydrosilylation reaction between a symmetrically substituted alpha, omega SiH- or alkenyl-terminated siloxane composed of a distinct di- or organopentasiloxane or organodecasiloxane blocks and an at the terminal units asymmetrically substituted siloxane with distinct monomodal di- or organopentasiloxane or decasiloxane blocks.
- 15

The polyorganosiloxanes (B) in compositions of invention has a viscosity in the range between 10 to 20 000 mPa.s at 25 °C at a shear rate of D=10 s⁻¹.

- 20 The inventive composition further comprises a crosslinker (C) selected from the group of silanes and siloxanes having reactive groups towards the reactive groups of component (B1) or (B2), whereby these reactive substituents of (C) are selected from the group which consists of SiH, alkenyl, alkoxy, amino, carboxy, epoxy, and thiol groups.

The polyorganosiloxanes (B2) are as defined before. The crosslinker component (C) can also be selected from the group of hydrocarbons without silicon atoms.

25

In general such crosslinkers are selected from the group which consists of

- a) di- or multifunctional silanes (R¹X)_xR¹_{3-x}Si-R or siloxanes having a group (R¹X)_xR¹_{3-x}Si-, whereby X, R¹, R are defined above, and

- b) di- or multifunctional epoxide with or without a silicon atom,
 - c) di- or multifunctional amine with or without a silicon atom,
 - d) di- or multifunctional carboxylic acids with or without a silicon atom, and
 - e) optionally alkenes or alkynes with di- or more unsaturated groups with or without a
- 5 silicon atom, such as trivinylcyclohexane, esters or ethers having di- or multi
unsaturated substituents.

In one embodiment of the compositions, the crosslinkers of (C) are selected from the group which consists of di- or multifunctional silanes of the type $(R^1X)_xR^{1_{3-x}}Si-R$ or siloxanes

10 having such reactive R^1-X groups. These crosslinkers are typically used in so-called Room Temperature Vulcanizing 1 Part (RTV-1K) or 2-Part composition (RTV-2K) rubber. Such compositions are characterized by a cure mechanism, wherein a condensation reaction takes place in the presence of organometal catalyst. Suitable crosslinkers are selected from the group of

$R^{15}_bSi(OR^1)_{4-b}$ e.g., alkylalkoxysilane

15 $R^{15}_bSi(OCOR^1)_{4-b}$ e.g., alkylacetoxysilane

$R^{15}_bSi(NR^1_2)_{4-b}$ e.g., alkyl-alkylaminosilane

$R^{15}_bSi(ON=R^1_2)_{4-b}$ e.g., alkyl-alkyloximosilane

$R^{15}_bSi(NHCOR^1_2)_{4-b}$ e.g., alkyl-alkylamido bzw. alkyl-arylamidodisilane,

$b = 0$ to 2 preferably 0 or 1,

20 the R^{15} group are selected from C1-C10 alkyl, alkoxyalkyl, C2-C8 alkenyl or phenyl.

Individual compounds are selected from e.g., tetraethoxysilane, polysilica esters, vinyltrialkoxysilane, methoxyethyl-trialkoxysilane, methyltrialkoxysilane, methyl-tris-benzamidodisilane, methyl-trisacetoxysilane, methyl-tris(trialkylamino)silane methyl-tris(trialkylaminoxyl)-silane, methyl-tris(butoximo)silane.

25 Those polyorganosiloxanes (B) which comprise reactive silyl groups of the type $(R^1X)_xR^{1_{3-x}}Si-$ can be cured by such a mechanism.

The crosslinkers (C) suitable for curing/crosslinking epoxy substituted polyorganosiloxane (B) are any kind of epoxy compounds with and without silicon or SiH silanes or siloxane compounds. If the crosslinker component (C) is selected from silicon-free compounds then small molecules

are preferred. The related curing is activated by heat, light, oxygen or humidity, if carried at room temperature it needs longer time to get a complete cure reaction in particular under assistance of humidity.

Component (D) - Catalyst

5 The composition of the invention optionally comprises the catalyst (D).

The catalyst (D) is selected from an inorganic or an organic peroxide, an azo compound, a hydrosilylation catalyst comprising an organometal compound, wherein the metals are chosen from Pt, Ru, Rh, Co Ni, Fe; and selected from an organometal or metal-free condensation catalyst, wherein the metals are chosen from Sn, Ti, Zr, Zn, Bi, Ce, Mn, Mo, V, Y, Yb, and a non-
10 metal a catalyst selected from amines, phosphates, phosphonates, and selected from a catalyst for the cationic polymerization such as light activatable iodonium, sulfonium salts and wherein the anions are chosen from group V-elements such as pentafluoro phosphate, pentafluoro arsenate, and pentafluoro antimonate.

The related catalysts (D) for the aforementioned condensation reaction are selected from the
15 group of a variety of organometal compounds preferably organo tin, titanium, zinc, iron, bismuth, calcium compounds but one can also use Lewis or Broensted acids or bases.

A preferred class of organometal compounds includes salts like dialkyltin oxides, reaction products of dialkyltin oxide with tetraalkoxsilanes, dibutyltindilaurate, stannous octoate, dibutyltin dioctoate, zinc octoate, tetraalkoxy titanates or alkoxy titanium chelates of C₁-C₁₀
20 carboxylic residues, etc. Specific examples of such catalysts are set forth and disclosed in column 3, lines 19- 54 of US 3,527,659 which is incorporated herein by reference. A particular useful curing catalyst for polyorganosiloxanes (B) having (R¹X)_xR¹_{3-x}Si- x=1-3 groups in this invention are quaternary ammonium salts such as benzyltrimethylammonium compounds like acetate, tetraalkylammonium acetate or other see US 3,819,745.

25 The amount of, *e.g.*, the tin catalyst is in the range of about 0.2 wt.% up to max. 2 wt.% of Sn in related organo metal compounds per polyorganosiloxane (B).

In preferred embodiment of the cure reaction epoxy groups present in the polyorganosiloxane (B) are cured respectively crosslinked by light activation of specific salts used as catalyst (D) to start a cationic polymerization. Such catalyst are onium salts used as photocatalyst (D) are previously described in the literature, e.g. in US 4,977,198 and in US 4,576,999. These photocatalysts (D) are the "onium" salts, of the general formulas:

$R^{16}_2I^+ MX_n^-$; $R^{16}_3S^+ MX_n^-$; $R^{16}_3Se^+ MX_n^-$, $R^{16}_4P^+ MX_n^-$; $R^{16}_4N^+ MX_n^-$; where different radicals represented by R^{16} can be the same or different organic radicals selected from C1-C30 aliphatic hydrocarbons, including aromatic carbocyclic radicals having 2 to 20 carbon atoms which optionally can be substituted.

- 10 The complex onium anion is selected from the group MX_n , wherein MX is a non-basic, non-nucleophilic anion, such as BF_4^- , PF_6^- , AsF_6^- , SbF_6^- , $SbCl_6^-$, HSO_4^- , ClO_4^- , and the like. The US 4,421,904 showing examples thereof is incorporated herein as reference.

Other onium catalysts are known in the art, like the borate types of EP 703236 or US 5,866,261 such as $B(C_6F_5)_4^-$ are incorporated by reference as well.

- 15 The photocatalysts or initiators may be mono- or multi-substituted mono, bis or trisaryl salts.

The complexed onium cation is selected from the elements of the group VII, VI and V.

- Typical compounds are bis-diaryl iodonium salts, such as bis(dodecyl phenyl)iodonium hexafluoroarsenate and bis(dodecyl phenyl) iodonium hexafluoroantimonate, and (4-octyloxyphenyl) (phenyl) iodonium hexafluoroantimonate are especially preferred within the MX types as catalyst see also US 4,421,904. These salts are the most preferred in practicing light induced curing of epoxysiloxanes.

In such systems sensitizers like isopropyl-thioxanthone sensitizer can also be present at a concentration of up to 15 mol.% of the iodonium salt disclosed in US 4,279,717.

The second group of catalysts (D) includes compounds selected from the group of free-radical photoinitiators, benzophenones and derivatives thereof, benzoin ethers, alpha-acyloxime esters, acetophenone and camphorquinone, derivatives, benzil ketals, ketone amine derivatives. Preferred examples of these photoinitiators include ethyl benzoin ether, isopropyl benzoin ether, dimethoxy-phenyl acetophenone and diethoxy acetophenone.

UV-curable compositions comprising epoxy but especially acrylic-functional silicone compounds can be made also by combining acrylic-functional silicones with unsaturated ester groups such as (Vle) with a catalytic amount of a free-radical-type photoinitiator which will effectively initiate crosslinking of the acrylic groups contained in the composition.

Brand names of such initiators are e.g. Darocure RTM.1173 (E. M. Chemicals) Irgacure 651 photoinitiator, a benzoin ether type free radical initiator available from Ciba-Geigy. The photoinitiators are generally used at a concentration of from about 0.1 wt.% to about 5 wt.% by weight related to the total weight of the coating composition (A) to (D).

The third group of catalysts (D) include selected from the group of thermo- or photo activatable radical initiating peroxy or azogroup containing compounds. Preferred photoinitiators are disclosed by Edwards US 3,211,795, Hatanaka, US 4,451,634 and Eckberg US 4,558,147, hereby incorporated by reference. Briefly, Eckberg disclosed certain perbenzoate esters having the general formula: $R^{18}-O-O-CO-C_6H_5-R^{19}$ wherein R^{18} is a monovalent alkyl or aryl group and R^{19} is hydrogen, alkyl, halogen, nitro, amino, or amido. Preferred perbenzoate esters include t-butylperbenzoate and its para-substituted derivatives, t-butyl-per-p-nitrobenzoate, t-butylper-p-methoxybenzoate, t-butylperoxy-p-methylbenzoate and t-butylperoxy-p-chlorobenzoate. In addition to t-butyl-perbenzoate and its derivatives as photo-initiators can also be suitable.

Peroxides can also be heat-activated and depending on the type of peroxide oxygen must be excluded somehow from the composition to be cured.

The amount of photoinitiator employed is not critical and is at least 0.5 part by weight, and it can be anywhere from about 0.5 to about 10 parts by weight based on 100 parts by weight of polyorganosiloxane (B).

As disclosed in US 4,882,201, the radiation-initiated cure of epoxysilicone films can be achieved by the use of UV-lamps such as: mercury arc lamps, Xenon arc lamps, high intensity halogen tungsten arc lamps, microwave driven arc lamps and lasers. The film or coated substrate is exposed to ultraviolet lamps, *e.g.* of about 200 Watts/inch. A clear, glossy layer can be obtained by curing in less than 1 second.

For crosslinkers of the SiH type the polyorganosiloxane (B2) group which make use of a hydrosilylation reaction the related hydrosilylation catalysts (D) are selected from the group of organo metal compounds, salts or metals, wherein the metal is selected from the group of Ni, Ir, Rh, Ru, Os, Pd and Pt compounds as taught in US 3,159,601; US 3,159,662; US 3,419,593; US 3,715,334; US 3,775,452 and US 3,814,730.

A preferred group of metal compounds are platinum compounds.

The catalyst (D) includes preferably complexes with sigma- and pi-bonded carbon ligands as well as ligands with S-, N, or P atoms, metal colloids or salts of the afore mentioned metals.

Preferred complexes are Pt(0)-alkenyl complexes, such alkenyl, cycloalkenyl, alkenylsiloxane such vinylsiloxane, because of its easy dispersibility in polyorganosiloxane compositions.

A particularly useful form of the platinum complexes are the Pt⁽⁰⁾-complexes with aliphatically unsaturated organosilicon compound such as 1,3-divinyltetramethyldisiloxane (Vinyl-M2 or Karstedt catalyst), as disclosed by US 3,419,593 incorporated herein by reference are especially preferred, cyclohexene-Pt, cyclooctadien-Pt and tetravinyltetramethyl-tetracyclosiloxane (vinyl-D4).

The amount of platinum as metal to be applied is preferably from 1 to 500 ppm, preferably 2 to 100 ppm, especially preferred 2 to 60 ppm, most preferred 2 to 15 ppm by weight of platinum per weight of the polyorganosiloxane component (B).

The hydrosilylation catalyst are preferably selected from the group of catalysts capable of being photoactivated.

These photo-activatable catalysts preferably contain at least one metal selected from the group composed of Pt, Pd, Rh, Co, Ni, Ir or Ru. The catalysts capable of being photoactivated preferably comprise platinum compounds.

Catalyst capable of being photo-activatable is preferably selected among organometallic compounds having ligands which, are preferably selected from sigma bonded alkyl or aryl groups, such as trisorganosilylalkyl groups, sigma-bonded silyl groups, like trialkyl silyl groups. Most preferred photo-activatable catalysts include η^5 -(optionally substituted)-cyclopentadienyl platinum complex compounds having sigma-bonded ligands, preferably sigma-bonded alkyl ligands, and also diketonates.

Further catalysts capable of being photoactivated include (η -diolefin)-(σ -aryl)-platinum complexes (see e.g. US 4,530,879).

Other examples of catalysts capable of being photo-activated include η -diolefin- σ -aryl-platinum complexes, such as disclosed in US 4,530,879, EP 122008, EP 146307 (corresponding to US 4,510,094 or US 2003/0199603, and US 4,640,939.

The most preferred catalysts capable of being photo-activated to be used in the process of the invention are (η^5 -cyclopentadienyl)-trimethyl-platinum, (η^5 -cyclopentadienyl)-triphenyl-platinum complexes, in particular, (η^5 -methylcyclopentadienyl)-trimethyl-platinum.

The related crosslinkers for the hydrosilylation reaction of these catalysts are defined above under component (B2).

This curing process is preferred since it provides high curing rates even for thick sections of > 1 to 50 mm and more whereby the curing temperature can be kept at temperatures below 50 °C.

Such curing temperatures are in particular necessary if the optical materials made out the composition of the invention are combined with temperature sensitive other electronic or optical materials.

The composition of the invention can in addition comprise an auxiliary component (E) for the adjustment of the processability. The component (E) is preferably selected from the group of organic and inorganic solvents or levelling agents, such as solvents having a boiling point below 250 °C at 1033 mbar. Example of such additives or solvents are in particular polyorganosiloxanes with 2 to 6 siloxy groups such as $(\text{me}_3\text{Si})_2\text{O}$, $(\text{me}_2\text{SiO})_{3-6}$, $\text{me}_3\text{SiO}-(\text{me}_2\text{SiO})_{1-4}-\text{Si}(\text{me}_3)_3$, benzene, toluene, xylene, C1-C8 alkyl alcohols, solvents usual for the coating industry.

One of the main ingredient of the inventive composition is the metal in the metal oxide/hydroxide component (A) which is selected from the group which consists of Ti, Zr, Hf, Sn, Ce, Al, As, In, Zn, Ge, Sb, Cr, Cd, W, Mo and Nb.

Such metal oxide /hydroxide nano particles are e.g. disclosed in WO 2012/058271 A2 and WO 2011/133228 A2. Nano particle suitable for optical application in compositions of high transparency and refractive index must provide particles below the wavelength of visible light. Therefore the particle size is preferably below 200 nm for the longest dimension of a diameter. In addition the maximum of possible refractive of any of the species needs to use particles which comprise at least to some extent crystalline compartments.

The component (A) can comprise more than one metal oxide/hydroxide i.e. mixed metal oxides containing a combination of two or more metallic elements in the same particle, or a mixture of two or more oxide particles. The metal oxide particles can have a particle size of approximately 100 nm or less; approximately 50 nm or less; approximately 25 nm or less; approximately 10 nm or less; even approximately 5 nm or less. In one embodiment, the metal-oxide particles have a particles size of from about 0.5 nm to about 100 nm; from about 1 nm to about 75 nm; from about 2 nm to about 50 nm; from about 5 nm to about 25 nm; even from about 7.5 nm to about 10 nm.

The metal oxide/hydroxide component (A) of this invention is composed of very narrowly distributed particle sizes between 2 – 7 nm. Such particles sizes can be determined by measuring the average particle size D_{50} in particular, determined by laser 'Dynamic Light Scattering with a Malvern Zetasizer, a method which is also known as photon correlation spectroscopy or quasi-elastic light scattering following ISO 13320-1 (see also

http://en.wikipedia.org/wiki/Dynamic_light_scattering). Although this method is the determination method of choice, in particular in a non-cured composition, in certain instances it is also sufficient to determine the average particle size D_{50} by electron microscopy (TEM).

- 5 The composition of the invention therefore comprises the metal oxide/hydroxide component (A) in a form which has a crystalline structure showing XRD reflexes and particles with a length in the range of less than 200 nm, preferably less than 100 nm, more preferably less than 20 nm. The term XRD reflexes means discretely scatters X-ray reflexes as shown *e.g.*, in WO 2011/133228 A2. It is believed that the presence of at least some areas of crystalline structures
- 10 is an assumption for a higher refractive index as desired. It has been found that any of the known disclosed surface treatments for blocking the agglomeration or sedimentation of the nano metal oxides in polysiloxanes is not sufficient, but could be overcome the polyorganosiloxanes (B) of the invention.
- 15 The composition of the invention contains higher concentrations of the high refractive metal oxide/hydroxide component (A). Since such nano fillers have the tendency to increase the viscosity up to a level which antagonizes a good processability it is preferred that the composition comprising the components (A) to (E) has a viscosity in the range of between 100 to 50 000 000 mPa.s at 25 °C at a shear rate of $D = 10 \text{ sec}^{-1}$.
- 20 In embodiments, the viscosity of the composition (A) and (B) has viscosity range between 100 to 1000 mPa.s at 25 °C and a shear rate of $D = 10 \text{ s}^{-1}$.

This level of viscosity is necessary for a sufficient processability in the manufacturing methods of the application where a film has to be formed by coaters or blades or where the inventive

25 composition must pass small channels/nozzles at a low pressure *e.g.* needles of syringes.

In one embodiment of the invention the composition comprising high concentrations of component (A) is diluted with a solvent to achieve a level of viscosity for a reasonable processability as indicated. Solvent means any evaporable organic or inorganic liquid having a boiling point below 250 °C at 1033 mbar. It is therefore desirable to have a viscosity range for

the component (A) in the inventive composition of 10 to 200 000 mPa.s more preferred 50 to 50 000 mPa.s at 25 °C at a shear rate $D = 10 \text{ s}^{-1}$, most preferred 50 to 5000 mPa.s at 25 °C, most preferred 100 to 1000 mPa.s at 25 °C and a shear rate of $D = 10 \text{ s}^{-1}$. In order to achieve such a relative low viscosity it is necessary on one hand to use a low viscous polyorganosiloxane (B) and in particular an embodiment of (B) which can work against the built-up of viscosity induced by component (A). This is one of the reasons to use a polyorganosiloxane (B) in which (B) has one terminal group for an interaction with the filler surface and a second more inert terminal group for the separation of the particles to each other.

The asymmetrically terminal substituted polyorganosiloxane (B) can also serve therefore as process aid in the process for the synthesis of the metal oxide/hydroxide particles wherein a metal alkoxide precursor is submitted to a hydrolysis and a condensation process, and wherein the leaving moieties of alcohol are removed by known technologies, such as esterification, extraction, evaporation and the like. In such condensation processes it is mandatory to control the particle size of the oxide/hydroxide in the course of the hydrolysis of the metal alkoxide. Another important step in the manufacturing of crystalline nano-sized metal oxide/hydroxide particles is the transformation from an amorphous modification into a crystalline modification. The asymmetrically terminal substituted polyorganosiloxane (B) can withstand for short time to the high temperature conditions which are necessary for this process step.

It is therefore in the scope of the invention to include a process for the manufacture of a crystalline component (A) according to the invention comprising the steps

- a) providing a dispersion of amorphous metal oxide/hydroxide particles optionally in a solvent,
- b) admixing the dispersion with a polyorganosiloxane (B),
- c) heating the mixture up to 450 °C ,
- d) optionally if necessary evaporating the solvent (E), and
- e) optionally admixing it with a further siloxane polymer (B).

After this process the crystalline metal oxide /hydroxide particles can be separated as dispersion or slurry and provided for the use in the inventive composition for making transparent films, coatings or articles.

The process for the manufacture of a curable transparent composition according to the invention comprising the steps

- i) providing a dispersion of a crystalline metal oxide /hydroxide particles of component (A) in a solvent,
- ii) admixing (A) with the polyorganosiloxane (B),
- iii) optionally heating the mixture,
- iv) evaporating if necessary the solvent (E) optionally after admixing it with a further siloxane polymer (C) and a catalyst (D).

A composition according to embodiments of the invention comprises the metal oxide/hydroxide particles (A) in an amount from about 0.01 to 350 part per weight (pt.wt.) per 100 pt.wt. of polyorganosiloxane (B).

An exemplary composition comprises the metal oxide/hydroxide particles (A) in an amount from about 0.001 to 95 weight %, (wt.%), more preferably 1 to 90 wt., a more preferred composition from about 25 to 85 wt.%, an even more preferred composition 35 to 75 wt.% related to component (B).

In one embodiment the inventive the composition comprises 350 pt.wt. component (A) of a metal oxide/hydroxide of a particle size below 200 nm comprising crystalline structures,

100 pt.wt. of component (B) an epoxy-functionalized polydimethylsiloxane selected from a symmetrically or an asymmetrically substituted component (B) comprising epoxy groups R^3 or R^6 ,

1 to 5 pt.wt. of an oninium salt of pentafluorophosphate as component (D)

0.5-1 pt.wt. of a sensitizer.

In embodiments, the composition comprises symmetrically and asymmetrically substituted polyorganosiloxane (B) and it is much more suitable that the composition comprises

only an asymmetrically polyorganosiloxane (B) whereby this component (B) has a refractive index n_D^{20} of more than 1.43.

In another embodiment the inventive the composition comprises

- 5 1-350 pt.wt. component (A) of a metal oxide/hydroxide of a particle size below 200 nm comprising crystalline structures,
 100 pt.wt. component (B) vinyl terminated polydiphenyldimethylsiloxane having more than 10 mol.-% phe_2SiO units,
 0 to 20 pt.wt. are of an asymmetrically substituted component (B) comprising the group
 10 R^4 and R^{4*} ,
 1 to 5 pt.wt. of a SiH polydimethylsiloxane (B2) having more than 10 mol.-% phe_2SiO units,
 An organometal Pt -compound as component (D) providing 2 to 500 ppm Pt related to the components (A) to (C).

15

In third preferred embodiment the inventive the composition comprises

- 1-350 pt.wt. component (A) of a metal oxide/hydroxide of a particle size below 200 nm comprising crystalline structures,
 100 pt.wt. are of an asymmetrically substituted component (B) comprising optical dense
 20 groups R, selected from the group which consist of R^{22} and $-\text{L}-\text{R}^{42}$,
 whereby more than 5 mol.-% of the siloxy units have substituents R^{22} and $-\text{L}-\text{R}^{42}$,
 1 to 5 pt.wt. of a SiH polydimethylsiloxane (B2),
 an organometal Pt -compound as component (D) providing 2 to 500 ppm Pt related to the components (A) to (C).

25

It is desirable that the composition comprises symmetrically and an asymmetrically substituted polyorganosiloxane (B) and it is more desirable that the composition comprises only an

asymmetrically polyorganosiloxane (B) whereby (B) has a refractive index n_D^{20} of more than 1.43.

It is even more preferred that the asymmetrically polyorganosiloxane (B) having a refractive index n_D^{20} of more than 1.43 consists of one group which can interact with the surface of the oxide/hydroxide (A) and a reactive group which can undergo a crosslinking reaction as defined above.

The invention includes also a process for curing the silicone composition according to the invention, wherein the components of (A), (B) and (C) as defined above are further mixed with at least one catalyst (D) selected from the group which consists of a heat or light-activatable radical initiator or a sensitizer, a heat or light-activatable hydrosilylation catalyst, a condensation catalyst and are submitted to a curing process wherein light, electromagnetic irradiation, heat, oxygen or humidity is applied, preferably at a temperature below 100 °C, more preferably below 80 °C.

The composition of the invention can be cured by reactions of a variety of reactive groups.

The reactive groups on the polyorganosiloxane (B) and component (C) are crosslinked by heat or light activation or diffusion of water or oxygen of the reactive groups R^2 , R^{22} , R^4 , R^{42} or R^7 , where these reactive group are selected from the group which consists of alkenyl, SiH, alkoxy, SiOH, amino, carboxy, epoxy, and thiol groups.

Depending on the process selected for the manufacture of the article a suitable process is chosen. There might be applications of the inventive composition where a curing of the composition is not necessary, *e.g.*, where the refractive composition is enclosed and used in a transparent containment or any kind of it.

In the majority of applications a curing step is preferred, *e.g.*, if a light guide or optical coating or other shaped articles shall be manufactured the composition of the invention is cured. If the application of heat is acceptable (< 110 °C few seconds) a radical initiated curing process with a radical initiator can be suitable, *e.g.*, using 0.1- 2 % of an organic peroxide and alkenyl siloxanes (B), but it is much better to use a heat assisted hydrosilylation since by-products of peroxides

can be avoided. In those cases the inventive composition can be cured preferable by a hydrosilylation reaction between SiH and alkenyl groups with a usual hydrosilylation catalyst but applying the lowest amount of reaction retarders like alkynols or a vinyl siloxane having vicinal vinyl groups. If there are stronger limitations for the applied curing temperature the crosslinking
5 step can be preferably achieved by the use of light activatable metal catalysts such platinum compounds as mentioned before. The last reaction is in particular preferred if thick sections must be cured, and therefore sensitizers must be avoided.

Other embodiments of light induced cure reactions make use of a radical initiated crosslinking reaction, *e.g.*, suitable for acrylic, methacrylic, alkenyl, thiol groups attached to (B). In a third
10 preferred embodiment a light induced cationic polymerization of epoxy groups with onium catalyst is used. This curing reaction is in particular useful for thin coatings or light guide, cladding materials of light guides.

The curing process for light curable compositions comprising in particular the polyorganosiloxanes (B) having groups selected from epoxy, alkenyl or thiol substituents can be
15 achieved with light in the range of 250 to 600 nm. The usual preferred light sources are UV-lamps known in the art for light curing polyorganosiloxanes.

The composition of the invention can be cured and formed to shaped in principle in the range of about 0 °C up to about 180 °C applied in an open oven chamber or by the walls of a mold, if
20 necessary a transparent mold or at least with a transparent window for compositions wherein the cure reaction is light activated.

The article can also be formed to a desired shape by passing through die of an extruder, as film applied with any coater, any blade, roll or in a mold optionally under pressure and then applying heat, or by self-leveling into any form, or by application of light or contact to humid air or
oxygen to activate the curing process and fix the shaped form.

25 The cured composition is intended for the use as optical device or in other applications where a higher refractive index is necessary. In order achieve a transparent composition comprising the nano metal oxide/hydroxide (A) and the polyorganosiloxane (B) the difference in the refractive indices between both materials shall not exceed a certain threshold value.

The invention therefore provides a fluid, a film, a cured coat, or shaped article formed by an extrusion or by a molding process consisting of a composition which comprises at least one polyorganosiloxane (B) with a refractive index n_D^{20} of about 1.43 at 25 °C or more.

- 5 The polyorganosiloxane (B) having a refractive index n_D^{20} of about 1.43 or more are composed according to the invention in that at least more than 5 mol.% of the optical dense substituents R^2 , R^{22} , R^3 , R^4 , R^{42} exceed this concentration. Preferably the properties of a higher refractive index are achieved by the insertion of optical dense substituents R^{22} and R^{42} at a concentration of more than 10 mol.%, more preferably more than 20 mol.% of the optical dense groups R^{22} and R^{42} related to all siloxy units comprising.

The selected range of increased concentration for the optical dense substituents is one assumption.

- The other assumption is that all substituents in particular R^{22} and R^{42} in the polyorganosiloxane (B) should have no light remarkable absorption (transmission > 80 % at 2 mm) or light scattering in the range of visible light between 350 to 2000 nm at, still acceptable between 400 to 1500 nm, but at minimum a (transmission > 80 % at 2 mm) between 400 to 1000 nm at 25 °C, i.e. low absorption.

- The inventive compositions comprising the metal oxide particles (A) and the polyorganosiloxane (B) have a refractive index n_D^{20} after removal of the solvent in the range from about 1.50 to 1.80, preferably from about 1.50 to 1.70, even more preferred from about 1.50 to 1.65.

- The preferred articles made according to the invention are therefore made out of a cured composition according to the invention applied as coat, as a shaped article made by an extrusion or molding process having a light transmission at wavelength between 300-2000 nm of about more than 85 % at a thickness of 2 mm. The preferred compositions are showing a light transmission of about >90 % or greater; more preferably about > 95 % or greater, even more preferred about 97 % or greater measured for at specimen in a cuvette of an UV photometer at a wavelength of 400 nm and a thickness of 2 mm at 25 °C.

The light absorption is measured as transmission of light for a concrete example at 400 nm or case wise at any distinct wavelength of interest in the range of 300 to 2000 nm.

In one embodiment the cured article has a gas permeability of a 1 mm thick sheet of about 50 $\text{cm}^3/\text{m}^2 \cdot 24 \text{ h} \cdot \text{atm}$ or greater; about 100 $\text{cm}^3/\text{m}^2 \cdot 24 \text{ h} \cdot \text{atm}$, 200 $\text{cm}^3/\text{m}^2 \cdot 24 \text{ h} \cdot \text{atm}$ or greater; even about 500 $\text{cm}^3/\text{m}^2 \cdot 24 \text{ h} \cdot \text{atm}$ or greater. In one embodiment, the cured article can have a Shore hardness of about Shore A of 10 ° to about Shore D of 50 °; from about Shore A of 20 ° to about Shore D 50 °.

The polyorganosiloxane (B) comprising the surface modified metal oxide/hydroxide particles (A) can be used to make a variety of products for a variety of applications. The siloxane polymers can be used to form coatings or films that can be applied onto the surface of other materials or that can be used to form products of a desired shape. The cured polyorganosiloxane compositions formed therefrom can exhibit relatively high refractive indexes and excellent mechanical properties and also avoid other problems associated with polymers comprising usual polyorganosiloxanes and particles having a high density and a high refractive index. The intended applications for compositions of the invention include, but not limited to, contact lenses, intraocular lenses solid state lighting encapsulants (light emitting diodes, organic light emitting diodes, laser diodes), waveguides (both planar and "fiber" geometries), optical computing, optical storage media, antireflection coatings, conformal coatings, optical lenses, micro-lenses, automobile topcoats, paint formulations and topcoats, hair care products, gradient refractive index optical components, dynamic gradient refractive index components, etc.

Aspects of the present subject matter can be understood with reference to the following examples. The examples are provided to illustrate possible embodiments of the present subject matter and are not intended to limit the disclosed subject matter.

Examples

The nano-sized metal oxide/hydroxide particles tested in the composition of the invention was a zirconium oxide/hydroxide dispersion named SH-6 supplied by Pixelligent Inc., synthesized in a hydrothermal reaction of an alkoxy zirconate according to WO 2012/058271. The SH-6 oxide contains 50 wt.% solids of zirconia particles of 7-10 nm size in length dispersed in toluene, whereby the solids comprise >85 wt.% zirconium oxide.

Example 1 Synthesis of an asymmetric substituted polyorganosiloxane $n\text{-C}_4\text{H}_9\text{-SiMe}_2\text{-O-[Me}_2\text{SiO]}_8\text{-SiMe}_2\text{-C}_2\text{H}_4\text{-Si(Ome)}_3$

This asymmetric polyorganosiloxane (B) was synthesized for the use as a dispersion aid or surface modifying agent to be applied in the next examples of compositions with a zirconia oxide /hydroxide. The asymmetric polyorganosiloxane with one reactive end group was prepared, which is here a trimethoxysilyl group. The precursor of the asymmetric siloxane molecule was $n\text{-C}_4\text{H}_9\text{-SiMe}_2\text{-O-[Me}_2\text{SiO]}_8\text{-SiMe}_2\text{-H}$ (MCR-H 07 from Gelest Inc.). It was reacted with vinyl trimethoxy silane in the presence of 10 ppm of Pt supplied by a Karstedt catalyst at 80 °C under N₂ atm. The resultant product formation is confirmed by ¹H and ²⁹Si-NMR and found to be formed in quantitative yields. The product is filtered through a layer diatomaceous earth (Celite) and used as such for further experimentations.

Comparison example : 2 – The dispersion of the unmodified commercial zirconia SH-6 (2 g) , without the inventive asymmetric polyorganosiloxane (B) was mixed into 91 g vinyl-terminated polydimethylsiloxane and an MD^{vi}Q resin. The vinyl terminated polydimethylsiloxane 'P 1' as component (B) has a refractive index of 1.406 and chain length of about in average 420 dimethylsiloxy units.

The mixture of this polyorganosiloxane (B) and the zirconium oxide/hydroxide dispersion result in an opaque non-transparent mixture.

Comparison example 3

Comparison example 2 is repeated whereby the polyorganosiloxane (B) is replaced by an usual commercial vinyl terminated polydimethylsiloxane with a viscosity of 200 mPa.s at 25 °C refractive index $n_D^{20} = 1.39$. The composition is opaque non-transparent mixture which began to show phase separation after removal of solvents.

Comparison example 4 Evaluation of $M-D_2D^{Ph}_2-D^{Vi}_2-M$ ('Phe 2') $n_D^{20} = 1.499$ without an asymmetric polyorganosiloxane (B)

Another mixture according to comparison example 2 was prepared wherein the vinyl-terminated polydimethyldiphenylsiloxane (B) 'Phe 1' of comparison example 2 has been replaced by a vinyl terminated polydimethyldiphenylsiloxane (B) $M-D_2D^{Ph}_2-D^{Vi}_2-M$ ('Phe 2') with a $n_D^{20} = 1.499$. In this mixture the concentration of the zirconia dispersion SH-6 was increased of up to 50 and 60 wt.% calculated on solids of zirconia. This mixture is showing a homogenous transparent appearance in a photometer cuvette (10 mm). Nevertheless there is still a bluish slight extent of haze. The refractive indices were measured to be $n_D^{20} = 1.569$ for 50 wt.% and $n_D^{20} = 1.588$ for 60 wt.% zirconium oxide/hydroxide solids. This example demonstrates that the zirconium oxide/hydroxide solids can be dispersed to obtain a transparent composition wherein the refractive index of the total composition is above of the refractive index of the polyorganosiloxane (B) 25 mol.% phenylsiloxy units ($=2/8$) comprising the optical dense groups.

Comparison example 5 – Process aid according to state of the art.

The evaluation of 3 additional alkoxysilanes as an example for process aids according to state of the art in a composition of a polyorganosiloxane of low refractive index and zirconia particles of SH-6 is shown in this example and in tab. 1. A composition was prepared wherein the polyorganosiloxane (B) of comparison example 4 is replaced by one polyorganosiloxane of lower refractive index 1.39 and to which the dispersion of the zirconia particles SH-6 acc. to comparison example 4 is admixed. In addition 3 different alkoxysilanes have been employed in order to evaluate their ability to work as possible dispersion aid.

The stirring conditions have been 40 °C for 30 min, whereby the solvent toluene and also the methanol of the alkoxy silanes were removed by evaporation under vacuum.

Tab.1

Comp. (A) solids SH-6 in PDMS (B) [wt.%]	Silane [wt %]	Silane type	Optical appearance
50	10	Vinyltrimethoxy silane	Opaque
50	10	Methacryloxy- propyltrimethoxysilane	Opaque
50	10	1-octenyl- trimethoxysilane	Opaque

This example demonstrate that the usual dispersion aids like the used alkoxy silanes of this test do not improve neither the transparency of the compositions comprising a non-inventive polyorganosiloxane and zirconium oxide/hydroxide particles nor do they improve the dispersibility of the metal oxide particles.

Comparison example 6

Comparison example 4 is repeated whereby the polyorganosiloxane (B) the $M-D_2D^{Ph}_2-D^{Vi}_2-M$ was replaced by a polydimethylsiloxanediol having a viscosity of 200 mPa.s at 25 °C.

During the stirring process a strong viscosity increase was observed beyond 100 000 mPa.s, i.e. the processability does not meet the requirements. In addition the composition was extreme opaque.

Example 7 –Compositions comprising ZrO_2 particles SH-6 an asymmetrically substituted polyorganosiloxane (B) according to the invention

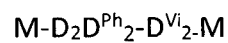
In a first mixture 0.65 g of the asymmetric polyorganosiloxane (B) of example 1 is added to 13.02 g of the zirconia dispersion SH-6 (50 wt.% in toluene = 6.5 g solids) and heated up to 60-70 °C for 1 hour to affect a possible reaction of the trialkoxysilyl groups of (B) with the reactive groups onto the surface of the zirconia oxide/hydroxide particles. The resultant dispersion has a clear appearance.

In a second it step 2.85 g of a second vinylterminated polydimethyldiphenylsiloxane (B) $\text{M-D}_2\text{D}^{\text{Ph}}_2\text{-D}^{\text{Vi}}_2\text{-M}$ ('Phe 2') $n_D^{20}=1.499$ of comparison example 3 was added.

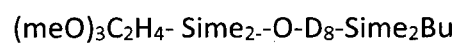
In a second part/mixture 0.4 g of the asymmetric polyorganosiloxane (B) of example 1 is were added to 6 g of the zirconia dispersion SH-6 (50 wt.% in toluene = 3 g solids) and 1,6 g of a polydimethyldiphenylmethylhydrogensiloxane $\text{M-D}_2\text{-D}^{\text{Ph}}_2\text{-D}^{\text{H}}_4\text{-M}$ (B2). After stirring the composition for 15 min at 60 °C the toluene was removed under vacuum. After evaporation a clear composition has been obtained showing high transparency with less or no bluish haze. The refractive index of the total composition is above of that the polyorganosiloxane (B) and is transparent.

Table 2

(1) Symmetric polymer (B1) Phe 2:



(2) Asymmetric polymer (B1):

(3) Symmetric crosslinker (C) =polymer (B2) Phe 2: $\text{MD}_2\text{D}^{\text{Ph}}_2\text{D}^{\text{H}}_2\text{M}$

Component (B) or (C)	Component (A) SH-6 [wt.%]	Component (B) asymm. (2) [wt.%]	optical appearance	RI n_d^{20}
3	-	-	transparent, low haze, low viscous	1.496
3	50	-	Milky, white fluid	
3	60	12	Bluish haze, homogenous sol	1.55
1	-	-	transparent, low haze, low viscous	1.50
1	50	-	translucent, hazy sol	1.57
1	60	12	transparent, low haze, low viscous	1.59

Example 8 – Curable Compositions comprising metal oxide (A) and polyorganosiloxane (B)**8.1**

A first part (K1) compositions is formed from a symmetric polyorganosiloxane (B) of the formula $M-D_2D^{Ph}_2D^{Vi}_2M$ (Phe 2) and zirconia particles SH-6 (A) modified with the asymmetric polyorganosiloxane (B) of Example 1.

A second part (K2) is formed from a polydimethyldiphenylmethylhydrogensiloxane (B2) $M-D_2D^{Ph}_2D^{H}_4M$ and the zirconia component (A) modified with polyorganosiloxane (B) of Example 1 as part (K2). Table 2 illustrates the refractive indices of the mixture of the parts K1 and K2 .

Table 3

Polymer-rest to 100 wt.%	Content of zirconia SH-6 [wt.%]	Asymm. (B) no. [wt.%]	R.I. n_D^{20}
$MD_2D^{Ph}_2D^{Vi}_2M$ =Phe 2 (K1)	0	0	<u>1.499</u>
$MD_2D^{Ph}_2D^{Vi}_2M$ (K1)	64	6	1.604
$MD_2D^{Ph}_2D^{H}_4M$ (K2)	64	10	1.590
Pt* in Phe 2 (K3)	-	-	1.5

* (K3) Part is a Pt Karstedt M^{Vi}_2 complex comprising 0.04 wt.% Pt in $M-D_2D^{Ph}_2D^{Vi}_2M$ applied at 10 ppm Pt concentration in the formulation.

The example demonstrates that the curable compositions with the vinyl component (B) + component (A) as well with the crosslinker component (C) or (B2) and component (A) are showing increased refractive index. The single packages the parts K1 and K2 as well as the mixture of both are transparent with very low haze. The refractive index of the composition (A) + (B) is above of the refractive index of the symmetric and the asymmetric polyorganosiloxane (B).

The concentration of optical dense siloxy groups with R22 is 25 mol.% (=2/8).

Example 8.2

Another set of reactive compositions (as part K1) and (K2) were admixed acc. to example 8.1. in order to measure the viscosities.

The part (K1) is composed of 52 wt.% ZrO₂ SH-6 component (A), 8.1 wt.% of the asymmetric polyorganosiloxane (B1) (meO)₃C₂H₄-Sime₂-O-D₈-Sime₂Bu, 39.9 wt.% of the symmetric polyorganosiloxane (B1) a polydimethyldiphenylsiloxane vinyl terminated M-D₂-D^{Ph}₂-D^{Vi}₂-M to obtain a viscosity of 8.39 Pa.s at 21 °C and a shear rate D=10 rads/sec.

The part (K2) is composed of 64 wt.% n-ZrO₂ component (A) SH-6, 10 wt.% of the asymm. polyorganosiloxane (B1) (meO)₃C₂H₄-Sime₂-O-D₈-Sime₂Bu, 26 wt.% of the symm. crosslinker (C) a polydimethyldiphenylmethylhydrogensiloxane (B2) M-D₂D^{Ph}₂-D^H₂-M trimethylsilyl-terminated to result a viscosity of 4.01 Pa.s at 21 °C and a shear rate D=10 rads/sec.

A mixture of the compositions were cured over 6 h at 100 °C whereby 10 ppm platinum is provided by a (K3) composition and submitted to a test where the discoloration has been measured expressed by the yellowness index and evaluated. Method: Macbeth Color Eye 7000 from Gretag Macbeth.

Table 4

Composition Parts K1 +K2 of ex 7	Ratio of K1 :K2	Optical appearance	R.I. n _D ²⁰ of cured film
K1+K2 + K3 (Pt 10 ppm)	1: 0.55	Highly transparent & brittle	~1.612

Since these cured compositions are suitable for applications in optical devices such as LED-lenses, light guides and other display applications it is required to maintain the clarity and colorless behavior for the function, e.g. as light guide. Any discoloration would be regarded as disadvantage. To evaluate the color properties of the film over time, the films are subjected to

accelerated weathering conditions such as dry heat or wet heat for extended periods of time. The cured compositions of zirconia (A) and polyorganosiloxane (B) the polydimethyldiphenylsiloxane based films of example 8 were exposed to 85 °C and 85 % relative humidity for 168 hours in order to simulate aging. It was found that there was no significant degradation of the cured composition in terms of discoloration demonstrated by the so-called $L^*a^*b^*$ -values and Yellowness Index. Table 5 illustrates test results of the cured films of compositions with polydimethyldiphenylsiloxane (B) without zirconia SH-6 component (A) and with component (A) under the aforementioned conditions.

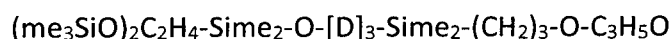
Table 5

Formulation acc. to example 7		Yellowness Index	L	a*	b*
Phe 2 no zirconia	Initial	0.15	96.28	-0.02	0.01
Phe 2 no zirconia	Aged) ²	0.1	96.19	-0.02	0.01
Phe 2 + zirconia	Initial	2.1	94.3	-0.12	1.2
Phe 2 +zirconia	Aged) ²	1.27	93.45	-0.09	0.76

)² 85 °C and 85 % relative humidity for 168 hours.

The value of the $L^*a^*b^*$ values and Yellowness Index are showing that the yellowing index decreased after ageing in both compositions with and without metal oxide (A).

Example 9 – Composition with ZrO₂ particles component (A) and with an asymmetric epoxy-trimethoxy terminated polyorganosiloxane (B)



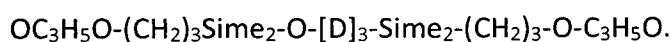
9.1.

A dispersion containing 50 g of ZrO₂ solids applied as 50 wt.% SH-6 dispersion in toluene was mixed under inert gas atmosphere with 5 g of the asymmetrically substituted epoxy- and trimethoxysilyl-terminated polyorganosiloxane (B) of the formula

$(\text{me}_3\text{SiO})_2\text{C}_2\text{H}_4\text{-Sime}_2\text{-O-[D]}_3\text{-Sime}_2\text{-(CH}_2\text{)}_3\text{-O-C}_3\text{H}_5\text{O}$ and stirred for 2 hrs at 55-60 °C. A transparent composition was obtained with no remarkable haze.

9.2.

The dispersion obtained in example 9.1. was further admixed with 5 g an symmetrically substituted polyorganosiloxane (B) with terminal epoxy substituents of the formula



A transparent composition could be achieved with no remarkable haze.

9.3.

Each of the composition of example 9.1 and 9.2 was then admixed with 10 g of a catalyst component (D) a solution of a bis(dodecylphenyl)idonium hexafluoroantimonate (47wt.%) with sensitizer 2-isopropylthioxanthone (2.4 %) and 4-isopropylthioxanthone (0.6 %) in C12-C14-alkylglycidyl ethers in order to prepare a UV-light curable epoxy composition.

Solvent-free material films on substrates were made using a spin-coater. Upon the exposure of the even films to UV-light required for initiating the polymerization process, highly transparent, high refractive layers of the compositions of the invention have been received.

Table 6

parts-by-weight (pt.wt)				n_D^{20} of the solid film 1 mm	Absorption loss
Component (A) ZrO_2 solids per SH-6	Comp. (B) asymm. subst.) ²	Comp. symm.(B)) ³	Catalyt (D)) ⁴		
5	0.5	-	1	1.716)*	~ 1 dB/cm)*
5	0.5	0.5	1	1.625)**	~ 1 dB/cm)**

)** n_D^{20} at 633 nm

)* n_D^{20} at 829 nm Films have been prepared on glass plate 5x5x0.7cm (length * width * thickness) whereby a solution was spincoating on a glass plate for 30 sec at 1500 rpm.

The refractive index measurements were done by ellipsometry with a Metricon-model 2010/M at 633 nm and 829 nm, more information via : <http://www.metricon.com/model-2010/>

)² asymm.component (B) as defined in example 8.2

)³ symm.component (B) as defined in example 8.2

)⁴ component (D) as defined in example 8.3.

The optical measurements have been conducted by TNO (Nederlandse Organisatie voor Toegepast-Natuurwetenschappelijk Onderzoek) Eindhoven, The Netherlands). We kindly would like to express our appreciation to TNO for their continuous help and support.

The polyorganosiloxane of example 9.1 contains 20 mol.% (=1/5); the symmetrically substituted polyorganosiloxane (B) of example 9.2 contains 25 mol.% (=2/8) of the optical dense group R^3 respectively R^{42} .

The results in tab. 6 are showing that the metal oxide particles of component (A) and polyorganosiloxanes (B) comprising the asymmetric polyorganosiloxane of the invention could

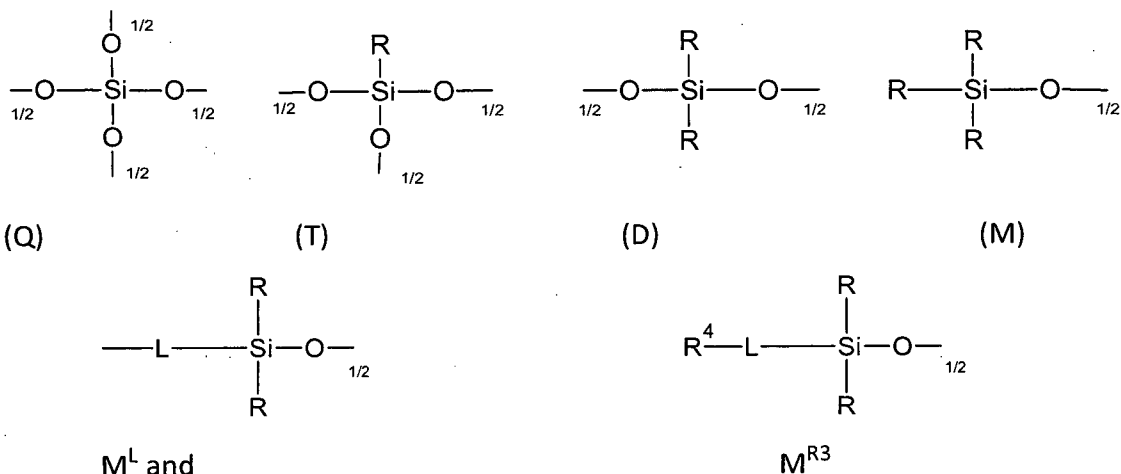
now be dispersed resulting in transparent composition having the refractive indices shown in table 5.

The examples show in addition that the metal oxide component (A) can already be dispersed in high concentration and provide a curable composition if the asymmetrically substituted polyorganosiloxane component (B) is used only.

Embodiments of the invention have been described above and modification and alterations may occur to others upon the reading and understanding of this specification. The claims as follows are intended to include all modifications and alterations insofar as they come within the scope of the claims or the equivalent thereof.

CLAIMS

1. A composition comprising metal oxide/hydroxide particles (A), one or more of a polyorganosiloxane (B), (B1) and (B2) selected from the group which consists of one or more substituted polyorganosiloxanes having units of the formulas (I),



wherein R are selected from the group of R^1 and R^2 , R^3 , R^4 , L, and

R^1 is selected from the group which consist of monovalent C1 to C22-alkyl, optionally substituted by Cl or F, and

R^2 which is selected from the group consisting of monovalent unsubstituted or substituted alkenyl groups selected from C2-C22-alkenyl, and including R^{22} which selected from C6-C22-cycloalkenyl, C7-C22-bicycloalkenyl, C6-C22-alkenylarylalkyl, optionally substituted by R^1 , bonded via a carbon atom of a hydrocarbon group to the silicon atom of the siloxy unit, which may be interrupted by O, N atoms, and

R^3 is a group ---L-R^4 forming M^{R^3} of formula (I), wherein

R^4 is selected from the group of R^1 , R^2 , R^{22} , hydrogen and a monovalent substituted or unsubstituted C4-C30-hydrocarbon unit optionally interrupted by ---NR^9 -, O, ---S--- or P atoms, substituted with R^1 , OH, Cl, F, CN, ---OR^9 ,

consisting of C1-C22-alkyl, poly (C2-C4)-alkylene oxide, OH, OR⁹, OC(O)R⁹, or R⁹ terminated (R¹X)_xR¹_{3-x}Si-, x= 1-3, X= C1-C8-alkoxy, C1-C8-alkylcarboxy, C1-C8-alkylamino, and

an ionic group derived from esters of carboxylic acids, S or P acids such as

R⁹-C(O)-O-, (R⁹-O)₂-P(O)-O-, (R⁹-O)₂-P(O)-, (R⁹-O)₂-P-O-, -NHR⁹-CH₂-COOH,

-NHR⁹-CH₂-O-S(O)₂(OH), -S-S(O)₂(OH)₂, whereby R⁹ is= hydrogen, C1-C8 alkyl, C2-C8 alkenyl, Me₃Si-,

and acid salts of amines, phosphines or preferably salts having quaternary -N⁺R⁹₃ or -P⁺R⁹₃ groups,

and including R⁴² selected from the group of R²², C6-C22-cycloalkyl, C6-C12-cyclothioalkyl, C7-C22-bicycloalkyl, C6-C22-aryl, C5-C12-hetero-N, -O, -S-aryl, C8-C22-polycyclic aryl, C7-C22-alkylaryl, C7-C22-arylalkyl, C8-C22-arylalkylene-arylalkyl, epoxides, of the group R², R²², and

R⁶_xR¹_{3-x}Si-, wherein x = 1-3,

R⁶= C6-C10-aryl, C7-C12-arylalkyl, C6-C12-cycloalkyl, C7-C16-bicycloalkyl, epoxy C3-C12-epoxy alkyl, C6-C12-cycloalkyl, epoxy C7-C16-bicycloalkyl,

C6-C12-thiocycloalkyl, C5-C12-hetereo-N, -O, -S-aryl,

bonded via a single bond or carbon bond of L to the silicon atom of the siloxy unit, whereby

L is a single bond, a divalent or trivalent group, which is selected from the group which consists of C1 to C12-alkylene groups, which can be interrupted by one or more -O-, - or -NR⁹ -C(O)-, and/or -NR⁹-, urethane -OC(O)NR⁹-, urea -NR⁹HC(O)NR⁹-, moieties, and substituted by one or more OH groups, bonded via a carbon bond to the silicon atom of the siloxy unit,

optionally one or more crosslinker (C)

selected in addition from the group of silicon-free unsaturated C6-C30-hydrocarbons having more than 2 unsaturated groups, C6-C30-hydrocarbons having epoxy groups

selected from the group of (B) consisting of the polyorganosiloxanes (B2) having an additional group R^7 , wherein R^7 is hydrogen attached to Si (SiH), optionally one or more of a curing catalyst (D) selected from the group of radical initiators, hydrosilylation catalysts, condensation catalysts, catalysts for light-activated cationic polymerization, characterized in that at least one component (B) comprises more than 5 mol.% siloxy units, which are substituted with R^{22} and R^{42} and has a refractive index n_D^{20} of more than 1.43 at 25°C.

2. The composition of claim 1, wherein the polyorganosiloxane (B) comprising the units M, D, T and Q has the structure of the empirical formula (II)



wherein:

$a = 0$ to 6,

$b = 0$ to 2000,

$c = 0$ to 50,

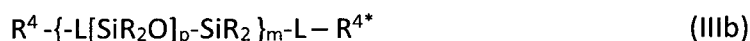
$d = 0$ or 1

$e = 0$ to 6

$f = 1$ to 200, if $d = 1$ or Q is present

wherein $a + c + d > 0$, and the viscosity at 25 °C is below 200 000 mPa.s at a shear rate at $D = 10 \text{ sec}^{-1}$.

3. The composition of claim 1 or 2, wherein the polyorganosiloxane (B) of the formula (I) or (II) is selected from the group of polyorganosiloxanes (B) consisting of symmetrical and asymmetrically substituted polyorganosiloxane (B) of formula (IIIa) to (IIIe)



$m = 1$ to 7

p= 1 to 9,

wherein

u= 0 to 500

v= 0-50

w = 0-500

$[M_{0.4-4}Q]_{1-200}$ (IIIc)

$[M_{0.4-4} D_{1-10} Q]_{1-200}$ (IIIId)

$M_{2-10}D_{0-500}T_{1-10}$ (IIIe),

wherein M and M* are selected from the group of M^{R1} , M^{R2} , M^{R3} ,

$$M^{R1} = R^1_3 SiO_{1/2}$$

$$M^{R2} = R^1_x R^2_{3-x} SiO_{1/2}$$

$$M^{R3} = R^1_x R^3_{3-x} SiO_{1/2}$$

x= 0 to 2

T selected from T^{R1} , T^{R2} , T^{R3} ,

$$T^{R1} = R^1 SiO_{3/2}$$

$$T^{R2} = R^2 SiO_{3/2}$$

$$T^{R3} = R^3 SiO_{3/2}$$

D is selected from D^{R1} , D^{R2} , D^{R3} ,

$$D^{R1} = R^1_2 SiO$$

$$D^{R2} = R^1_y R^2_{2-y} SiO$$

$$D^{R3} = R^1_y R^3_{2-y} SiO$$

y= 0 to 1,

characterized in that at least one polyorganosiloxane (B) comprises more than 5 mol.% of siloxy units which are substituted with R^{22} and R^{42} .

4. The composition of any of claims 1 to 3, wherein at least one of the polyorganosiloxanes (B) is selected from the group of formula $M^{R2}-D^{R1}_u-D^{R2}_v-D^{R3}_w-M^{R2}$,

$[M_{0.4-4}Q]_{1-200}$,

$[M_{0.4-4} D_{1-10} Q]_{1-200}$,

$M_{2-10}D_{0-500}T_{1-10}$, and

$M_{2-10}D_{0-500}T_{1-10}$, wherein

the M and M* units are selected from the group of $M^{R^1}, M^{R^2}, M^{R^3}$,

the D units are selected from $D^{R^1}, D^{R^2}, D^{R^3}$,

the T units are selected from $T^{R^1}T^{R^2}, T^{R^3}$ as defined before,

whereby R1 = methyl, 3,3,3-trifluoropropyl

u= 0 to 200

v= 0-20

w= 1 to 200 and

$R^4 - \{ -L[SiR_2O]_p - SiR_2 \}_m - L - R^{4*}$,

R^2 is selected from vinyl, allyl, hexenyl, octenyl, R^{22} is selected from cyclohexenylethyl, limonyl, norbornenyl, norbornenethyl, vinylphenylethyl, C2-C8-alkenylphenylether, C2-C8-alkenylbiphenylether, allyloxyphenyloxypropyl

$R^3 = -L-R^4$, wherein,

L is a single bond, a divalent C1 to C8-alkylene groups, which can be interrupted by one or more O, - or N -C(O)-, and/or $-NR^9$ - moieties, and substituted by one or more OH groups,

$R^4 =$ which is selected from the group of R^1, R^2, R^{22} , hydrogen,

$(R^1X)_xR^{13-x}Si-$, wherein $x = 1-3$, $X =$ C1-C8-alkoxy, C1-C8-alkylcarboxy, C1-C8-alkylamino ,

and an ionic group derived from esters of carboxylic acids, S or P acids such as

$R^9-C(O)-O-$, $(R^9-O)_2-P(O)-O-$, $(R^9-O)_2-P(O)-$, $(R^9-O)_2-P-O-$, $-NHR^9-CH_2-COOH$,

$-NHR^9-CH_2-O-S(O)_2(OH)$, $-S-S(O)_2(OH)_2$, wherein R^9 is= hydrogen, C1-C8 alkyl, C2-C8 alkenyl, me_3Si- ,

and acid salts of amines, phosphines or preferably salts having quaternary $-N^+R_3$ or $-P^+R_3$ groups, and R^4 selected from R^{42}

cyclohexyl, norbornyl, phenyl, phenylpropyl, phenylethyl, substituted hydroxyphenyl, eugenol, cumylphenoether, bisphenoethers, naphthyl, C5-C12-thiophene, C8-C12-indol, C12-C22-carbazol, C4-C12-dioxolane, C5-C12-thiophene, C3-C12-1,3-dithiolane, C3-C12-1,3,5-trithiane, C4-C2-1,3-dithiane, C5-C12-tetrahydro-2H-thiopyran, C6-C12-epoxyalkyl, C6-C22-epoxycycloalkyl, optionally interrupted by

-NR⁹-, O, -S- or P atoms, substituted with R¹, OH, Cl, F, CN, -OR),

and

R⁶_xR¹_{3-x}Si-, wherein x= 1-3 ,

R⁶= C6-C10-aryl, C7-C12-arylalkyl, C6-C12-cycloalkyl, C7-C16-bicycloalkyl, epoxy C3-C12-epoxy alkyl, C6-C12-cycloalkyl, epoxy C7-C16-bicycloalkyl,

C6-C12-thiocycloalkyl, C5-C12-hetereo N, O, S-aryl,

bonded via L to the silicon atom of the siloxy unit, whereby at least one component (B) comprises more than 10 mol.% siloxy units which are substituted with R²² and R⁴².

5. The composition of any of claims 1 to 4, wherein at least one of the polyorganosiloxanes (B) is selected from the group of formula M^{R3}-D^{R1}_u-D^{R2}_v-D^{R3}_w- M^{R3}

whereby R¹ = methyl, 3,3,3-trifluoropropyl

u= 0 to 100

v= 0-10

w= 1 to 100 and

R² is selected from vinyl, allyl, hexenyl, octenyl, R²² is selected from cyclohexenylethyl, limonyl, norbornenylethyl, vinylphenylethyl, C2-C8-alkenylphenylether, C2-C8-alkenylbiphenylether, allyloxyphenyloxypropyl

R³= -L-R⁴,

and L is defined above,

R^4 is selected from the group of $(R^1X)_xR^{13-x}Si-$, wherein $x = 1-3$, $X =$ C1-C8 alkoxy, C1-C8-alkylcarboxy, C1-C8-alkylamino,

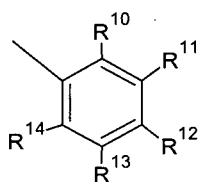
and an ionic group derived from esters of carboxylic acids, S or P acids such as $R^9-C(O)-O-$, $(R^9-O)_2-P(O)-O-$, $(R^9-O)_2-P(O)-$, $(R^9-O)_2-P-O-$, $-NHR^9-CH_2-COOH$, $-NHR^9-CH_2-O-S(O)_2(OH)$, $-S-S(O)_2(OH)_2$, quaternary $-N^+R^9_3$,

and

$R^{42} =$ cyclohexylethyl, norbornyl, norbornylethyl, phenyl, phenylethyl, phenylpropyl, naphthyl, eugenol, bisphenolethers, cumylphenolether, glycidylpropylether, epoxylimonyl, epoxycyclohexanethyl, epoxynorbornyl, 1,3-dithiolane, 1,3,5-trithiane, 1,3-dithiane, thiophenyl, tetrahydro-2H-thiopyranyl, carbazol, indol, trisphenylsilyl, and

R^6me_2Si- , wherein $R^6 =$ C6-C10-aryl, C7-C12-arylalkyl, C6-C12-cycloalkyl, C7-C16-bicycloalkyl, C6-C12-cyclothioalkyl, C5-C12-hetreo-N, -O, -S-aryl, optionally substituted by R^1 , OH, Cl, and a silyl ether group $R^{13}Si-O-$,

and of unsubstituted or substituted oxyphenyl moieties, whereby the group



is substituted with R^{10} to R^{14} ,

wherein R^{10} , R^{14} is hydrogen or R^1 and

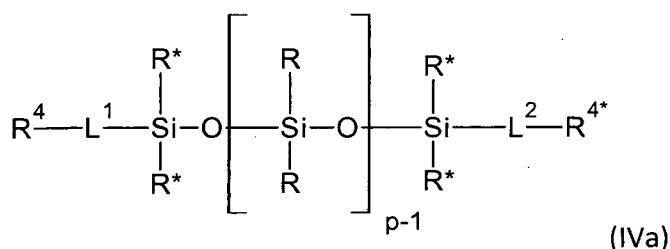
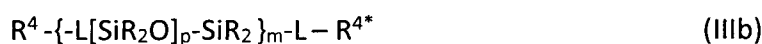
R^{11} , R^{12} , R^{13} are selected from $-O-R^9$,

wherein at least one of the groups R^{11} to R^{13} are OH,

bonded via L to the silicon atom of the siloxy unit,

whereby at least one component (B) comprises more than 10 mol.% siloxy units which are substituted with R²² and R⁴².

6. The composition of any of claims 1 to 5 wherein at least one the polyorganosiloxane (B) has the structure selected from the groups of the formulas (IIIa), (IIIb), and (IVa)



R, R^* can be different and are selected from the group which consists of $R^1, R^2, R^{22}, R^3, R^4, R^{42}$ as defined above,

wherein the terminal groups R^4 and R^{4*} are selected from R^4 and R^{42} defined above but are different to each other,

$p = 0$ or 4 or 8

R¹ = methyl,

$$R^3 = -L - R^4$$

whereby L is selected from L1 and L2 are divalent C1 to C8-alkylene groups, which can be interrupted by one or more O, - or N -C(O)-, and/or -NR⁹- moieties, and substituted by one or more OH groups,

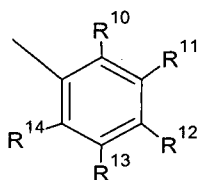
R² is selected from the group which consists of vinyl, hexenyl, octenyl R²² = limonyl, cyclohexenylethyl, vinylphenylethyl, C2-C8-alkenylphenylether, C2-C8-alkenylbiphenylether, allyloxyphenyloxypropyl,

R^4 is and $(R^1X)_xR^{13-x}Si-$, wherein $x = 1-3$, $X =$ C1-C8 alkoxy, C1-C8-alkylcarboxy, C1-C8-alkylamino, and

selected from the group R^{42} which consists of R^{22} , phenyl, phenylethyl, phenylpropyl, naphthyl, eugenol, bisphenoethers, cumylphenoether, norbornyl, glycidylpropylether, cyclohexenoxide ethyl, limonyloxide, norbornyloxide, 1,3-dithiandimethylsilyl, trisphenylsilyl,

R^6me_2Si- , wherein $R^6 =$ phenylethyl, phenylpropyl, eugenol, limonyl, epoxylimonyl, glycidylpropylether epoxycyclohexylethyl, norbornenylethyl, epoxy norbornenylethyl, carbazol, indol, and

of unsubstituted or substituted oxyphenyl moieties, whereby the group



is substituted with R^{10} to R^{14} ,

wherein R^{10} , R^{14} is hydrogen or R^1 and

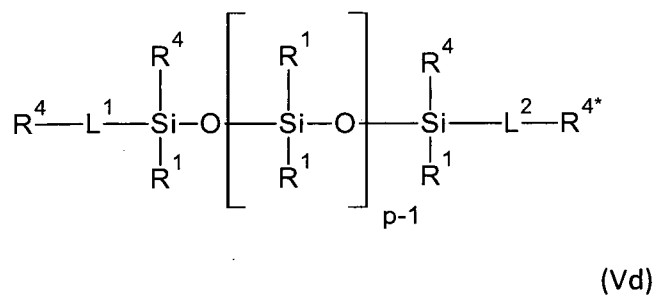
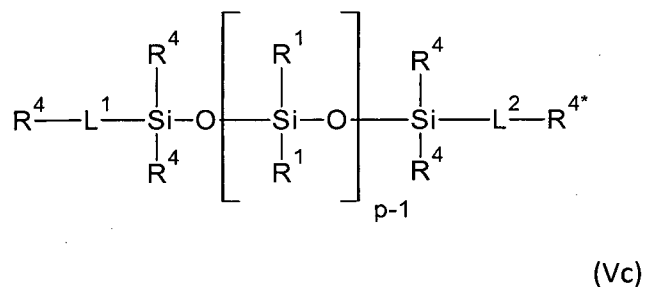
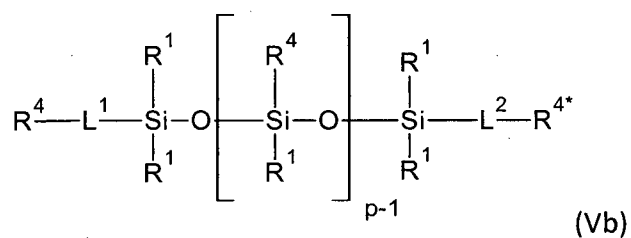
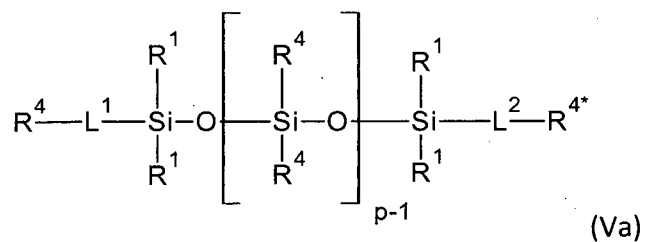
R^{11} , R^{12} , R^{13} are selected from $-OR^9$,

wherein at least two of the groups R^{11} to R^{13} are OH,

bonded via L to the silicon atom of the siloxy unit, whereby at least one component (B) comprises more than 10 mol.% siloxy units which are substituted with R^{22} and R^{42} .

7. The composition of any of claims 1 to 6, wherein the polyorganosiloxane (B) is selected from the formula $M^{R^3}-D^{R^1}_u-D^{R^3}_w-M^{R^3*}$

wherein R^3 , R^{3*} are $-L-R^4$ or $-L-R^{4*}$ and the groups R^4 and R^{4*} selected from R^4 and R^{42} and are different to each other and whereby the polyorganosiloxane (B) is selected from group of the structural formulas



R¹ = methyl,

R⁴ and R^{4*} as defined in claim 6,

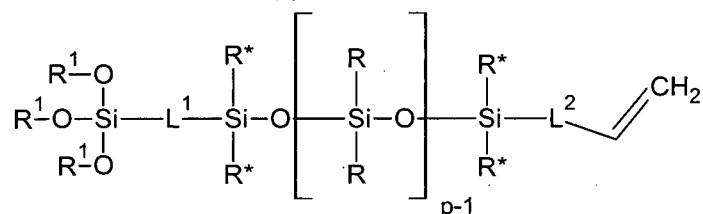
L¹ and L² are selected from the group L as defined above,

whereby L¹ and L² are divalent C1 to C8-alkylene groups, which can be interrupted by one or more O, - or N-C(O)-, and/or -NR⁹- moieties, and substituted by one or more OH groups,

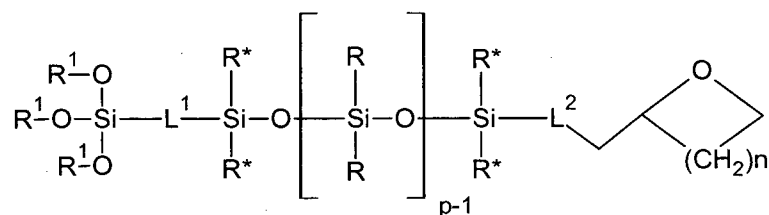
substituted with groups selected from R^{22} and R^{42} .

formulas (Vla) to (Vle),

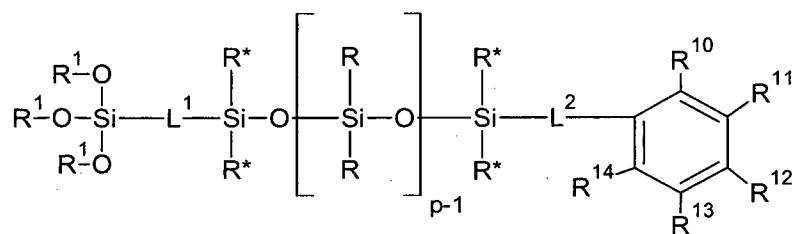
wherein R and R* are selected from R¹ and R⁴ and R and R* can be different



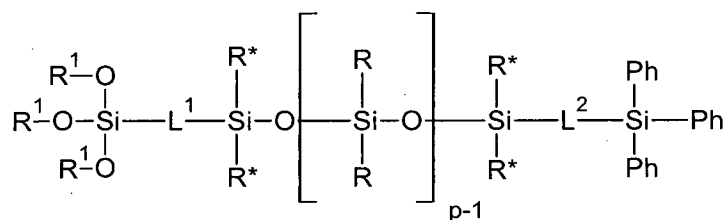
(VIa)



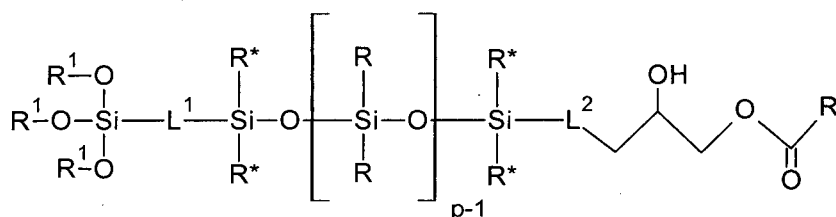
(Vib)



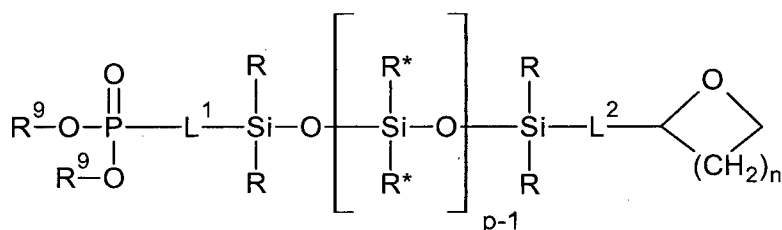
(Vlc)



(VId)



(VIe)



(VIf)

R, R* = methyl, 3,3,3-fluoropropyl, R⁴, R⁴²,

p = 1 or 4 or 9

n = 0-6

R² is selected from the group which consists of vinyl, hexenyl R²² = limonyl, cyclohexenylethyl, norbornenylethyl, vinylphenylethyl, C2-C8-alkenylphenylether, C2-C8-alkenylbiphenylether, allyloxyphenyloxypropyl

R³ = -L-R⁴

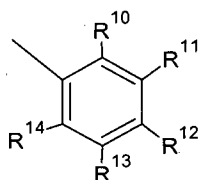
wherein L is selected from L1 and L2 are divalent C1 to C8-alkylene groups, which can be interrupted by one or more O, - or N -C(O)-, and/or -NR⁹- moieties, and substituted by one or more OH groups,

R⁴ is and (R¹X)ₓR¹₃₋ₓSi-, wherein x = 1-3, X = C1-C8 alkoxy, C1-C8-alkylcarboxy, C1-C8-alkylamino, and

selected from the group R⁴² which consists of phenyl, phenylethyl, phenylpropyl, naphthyl, eugenol, bisphenoethers, cumylphenoether, R²² which consists of norbornyl, glycidylpropylether, cyclohexenoxide ethyl, limonyloxide, norbornyloxide, 1,3-dithiandimethylsilyl, trisphenylsilyl,

$R^6\text{me}_2\text{Si}-$, wherein R^6 = phenylethyl, phenylpropyl, eugenol, limonyl, epoxyliomonyl, glycidylpropylether epoxycyclohexylethyl, norbornenylethyl, epoxy norbornenylethyl, carbazol, indol,

of unsubstituted or substituted oxyphenyl moieties, whereby the group



is substituted with R^{10} to R^{14} ,

wherein R^{10} , R^{14} is hydrogen or R^1 and

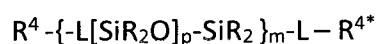
R^{11} , R^{12} , R^{13} are selected from $-\text{OR}_9$,

whereby at least two of the groups R^{11} to R^{13} are OH,

bonded via L to the silicon atom of the siloxy unit, whereby at least one component (B) comprises more than 10 mol.% siloxy units which are substituted with R^{22} and R^{42} .

9. The composition of any of claims 1 to 8 wherein the composition comprises at least two polyorganosiloxanes (B) wherein one is an asymmetrically substituted polyorganosiloxane (B) comprising two different groups R^3 and R^{3*} respectively $-\text{L}-R^4$ and $-\text{L}-R^{4*}$ at the terminal siloxy units of the polyorganosiloxane (B) according to claim 5.

10. The composition of any of claims 1 to 9, wherein at least one of the polyorganosiloxane (B) is selected from group of the formula (IIIb)



L, R^4 are as defined before in claim 1 - 9

R is selected from R^1 , and R^3 ,

$p=1$ or 4

$m=1$ to 7 .

11. The composition of any of claims 1 to 10, wherein the composition further comprises a crosslinker (C) selected from the group which consists of silanes and siloxanes having reactive groups towards the reactive groups of component (B1) or (B2), whereby these reactive substituents of the crosslinker component (C) are selected from the group which consists of SiH, alkenyl, alkoxy, amino, carboxy, epoxy, and thiol groups.
12. The composition of claim 11 wherein the composition comprises at least a third polyorganosiloxane (B2) which has an addition group R^7 , whereby R^7 is hydrogen in a SiH group.
13. The composition of any of claims 1 to 12, wherein at least one polyorganosiloxane (B) comprises more than 20 mol.% of the siloxy groups which are substituted with the optical dense groups R^{22} or R^{42} .
14. The composition of any of claims 1 to 12 wherein the polyorganosiloxane (B) has a viscosity in the range between 10 to 200 000 mPa.s at 25 °C at a shear rate of $D=10\text{ s}^{-1}$.
15. The composition of any of claims 1 to 14, wherein the composition further comprises a crosslinker (C) selected from the group of hydrocarbons without silicon atoms,
16. The composition of any of claims 1-15, wherein the catalyst (D) is selected from an inorganic or an organic peroxide, an azo compound, a hydrosilylation catalyst comprising an organometallic compound, wherein the metals are chosen from Pt, Ru, Rh, Co Ni, Fe; and selected from an organometallic or metal-free condensation catalyst, wherein the metals are chosen from Sn, Ti, Zr, Zn, Bi, Ce, Mn, Mo, V, Y, Yb, and a non-metal a catalyst selected from amines, phosphates, phosphonates, and selected from a catalyst for the cationic polymerization such as light activatable iodonium, sulfonium salts and wherein the anions are chosen from group V-elements such as pentafluoro phosphate, pentafluoro arsenate, and pentafluoro antimonate.

17. The composition of any of claims 1-16, wherein the metal in the metal oxide/hydroxide component (A) is selected from the group which consists of Ti, Zr, Hf, Sn, Ce, Al, As, In, Zn, Ge, Sb, Cr, Cd, W, Mo and Nb.

18. The composition of any of claims 1-17, wherein the metal oxide/hydroxide component (A) has a crystalline structure showing XRD reflexes and particles with a length in the range of less than 200 nm.

19. The composition of claim 1 to 18, wherein the composition comprising the components (A) to (E) has a viscosity in the range of between 100 to 50 000 000 mPa.s at 25 °C at a shear rate of $D = 10 \text{ sec}^{-1}$.

20. Process for the manufacture of a crystalline component (A) according to claim 1-19 comprising the steps

- a) providing a dispersion of amorphous metal oxide/hydroxide particles optionally in a solvent,
- b) admixing the dispersion with a polyorganosiloxane (B),
- c) heating the mixture up to 450 °C ,
- d) optionally if necessary evaporating the solvent (E), and
- e) optionally admixing it with a further siloxane polymer (B).

21. Process for the manufacture of a curable composition according to claim 1 to 19 comprising the steps

- i) providing a dispersion of a crystalline metal oxide /hydroxide particles of component (A) in a solvent,
- ii) admixing (A) with the polyorganosiloxane (B),
- iii) optionally heating the mixture,

iv) evaporating if necessary the solvent (E) optionally after admixing it with a further siloxane polymer (C) and a catalyst (D).

22. A composition according to claim 1 to 21 comprising the metal oxide/hydroxide particles (A) in an amount from about 0.001 to 95 weight percent relative to component (B).
23. A composition comprising of
350 pt.wt. component (A) of a metal oxide/hydroxide of a particle size below 200 nm comprising crystalline structures,
100 pt.wt. of component (B) an epoxy functionalized polydimethylsiloxane selected from a symmetrically or an asymmetrically substituted component (B) comprising epoxy groups R^3 or R^6 ,
1 to 5 pt.wt. of an oninium salt of pentafluorophosphate as component (D)
0.5-1 pt.wt. of a sensitizer.
24. A composition comprising of
1-350 pt.wt. component (A) of a metal oxide/hydroxide of a particle size below 200 nm comprising crystalline structures,
100 pt.wt. component (B) vinyl terminated polydiphenyldimethylsiloxane having more than 10 mol.-% phe_2SiO units,
0 to 20 pt.wt. are of an asymmetrically substituted component (B) comprising the group R^4 and R^{4*} ,
1 to 5 pt.wt. of a SiH polydimethylsiloxane (B2) having more than 10 mol.-% phe_2SiO units,
An organometal Pt-compound as component (D) providing 1 to 500 ppm Pt related to the components (A) to (C).
25. A composition comprising of

1-350 pt.wt. component (A) of a metal oxide/hydroxide of a particle size below 200 nm comprising crystalline structures,
100 pt.wt. are of an asymmetrically substituted component (B) comprising optical dense groups R, selected from the group which consist of R^{22} and $-L-R^{42}$,
whereby more than 5 mol.% of the siloxy units have substituents R^{22} and $-L-R^{42}$,
1 to 5 pt.wt. of a SiH polydimethylsiloxane (B2),
an organometal Pt-compound as component (D) providing 1 to 500 ppm Pt related to the components (A) to (C).

26. A process for curing the silicone composition according of claim 1 to 25, wherein the components of claim 1 are further mixed with at least one catalyst selected from the group which consists of a heat or light-activatable radical initiator or a sensitizer, a heat or light-activatable hydrosilylation catalyst, a condensation catalyst and are submitted to a curing process wherein light, electromagnetic irradiation, heat, oxygen or humidity is applied.

27. A cured composition according to of claim 1 to 25, wherein the reactive groups on the polyorganosiloxane (B) and component (C) are crosslinked by heat or light activation or diffusion of water or oxygen of the reactive groups R^2 , R^{22} , R^4 , R^{42} or R^7 , where these reactive group are selected from the group which consists of alkenyl, SiH, alkoxy, SiOH, amino, carboxy, epoxy, and thiol groups.

28. A fluid, a film, a casted or dispensed coat, a shaped article formed by an extrusion or by a molding process consisting of a composition of claim 1-25 which comprises at least one polyorganosiloxane (B) with a refractive index n_D^{20} of about 1.43 or more.

29. A cured composition according to claim 28 applied as casted, dispensed coat, film shaped article made by an extrusion or molding process having a light transmission at wavelength between 300-2000 nm of about more than 85 % at a thickness of 2 mm.

INTERNATIONAL SEARCH REPORT

International application No
PCT/EP2016/001267

A. CLASSIFICATION OF SUBJECT MATTER
INV. C08L83/04 C08L83/06
ADD.

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)
C08G C08L

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

EPO-Internal, WPI Data

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	WO 2014/046309 A1 (DOW CORNING TORAY CO LTD [JP]) 27 March 2014 (2014-03-27) paragraphs [0009], [0010], [0014] - [0052] paragraphs [0131], [0133]; example 6; table 2	1-19,21, 22,25-29
X	----- DATABASE WPI Week 201007 Thomson Scientific, London, GB; AN 2010-A56765 XP002763215, & JP 2010 007057 A (TORAY IND INC) 14 January 2010 (2010-01-14) abstract ----- -/-	1-19,21, 22,25-29



Further documents are listed in the continuation of Box C.



See patent family annex.

* Special categories of cited documents :

"A" document defining the general state of the art which is not considered to be of particular relevance

"E" earlier application or patent but published on or after the international filing date

"L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)

"O" document referring to an oral disclosure, use, exhibition or other means

"P" document published prior to the international filing date but later than the priority date claimed

"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention

"X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone

"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art

"&" document member of the same patent family

Date of the actual completion of the international search

9 December 2016

Date of mailing of the international search report

16/12/2016

Name and mailing address of the ISA/

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Authorized officer

Stinchcombe, John

INTERNATIONAL SEARCH REPORT

International application No
PCT/EP2016/001267

C(Continuation). DOCUMENTS CONSIDERED TO BE RELEVANT		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	US 8 173 743 B2 (HIRANO KEISUKE [JP]) 8 May 2012 (2012-05-08) column 1, line 56 - column 6, line 3 examples 1-13 -----	1-19,21, 22,25-29
X	US 8 329 290 B2 (HIRANO KEISUKE [JP]) 11 December 2012 (2012-12-11) column 2, line 62 - column 20, line 16 examples -----	1-19,21, 22,25-29
X	US 2010/036051 A1 (HIRANO KEISUKE [JP]) 11 February 2010 (2010-02-11) paragraphs [0008] - [0042] examples 1-5,8-12 -----	1-19,21, 22,25-29
X	US 7 834 083 B2 (SHIN HYEON JIN [KR] ET AL) 16 November 2010 (2010-11-16) column 1, line 52 - column 3, line 3 column 8, line 3 - line 34 pages 1-3 -----	23,26-29
A	US 2007/004871 A1 (LU QIWEI [US] ET AL) 4 January 2007 (2007-01-04) paragraphs [0007], [0019] - [0021], [0025] -----	23,26-29
A	US 4 421 904 A (ECKBERG RICHARD P [US] ET AL) 20 December 1983 (1983-12-20) cited in the application column 5, line 39 - line 61 -----	23,26-29

INTERNATIONAL SEARCH REPORT

International application No.
PCT/EP2016/001267

Box No. II Observations where certain claims were found unsearchable (Continuation of item 2 of first sheet)

This international search report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:

1. ☐ Claims Nos.:
because they relate to subject matter not required to be searched by this Authority, namely:
2. ☐ Claims Nos.:
because they relate to parts of the international application that do not comply with the prescribed requirements to such an extent that no meaningful international search can be carried out, specifically:
3. ☐ Claims Nos.:
because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).

Box No. III Observations where unity of invention is lacking (Continuation of item 3 of first sheet)

This International Searching Authority found multiple inventions in this international application, as follows:

see additional sheet

1. ☐ As all required additional search fees were timely paid by the applicant, this international search report covers all searchable claims.
2. ☐ As all searchable claims could be searched without effort justifying an additional fees, this Authority did not invite payment of additional fees.
3. ☒ As only some of the required additional search fees were timely paid by the applicant, this international search report covers only those claims for which fees were paid, specifically claims Nos.:
1-19, 21-23, 25(completely); 26-29(partially)
4. ☐ No required additional search fees were timely paid by the applicant. Consequently, this international search report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.:

Remark on Protest

- ☐ The additional search fees were accompanied by the applicant's protest and, where applicable, the payment of a protest fee.
- ☐ The additional search fees were accompanied by the applicant's protest but the applicable protest fee was not paid within the time limit specified in the invitation.
- ☒ No protest accompanied the payment of additional search fees.

FURTHER INFORMATION CONTINUED FROM PCT/ISA/ 210

This International Searching Authority found multiple (groups of) inventions in this international application, as follows:

1. claims: 1-19, 21, 22, 25(completely); 26-29(partially)

Composition comprising metal oxide/hydroxide particles and polyorganosiloxane with at least one component with more than 5 mol.% siloxy units substituted at least with C6-C22-cycloalkenyl, C7-C22-bicycloalkenyl and C6-C22-alkenylarylalkyl groups. Processes for its manufacture. Process for its cure. Cured composition.

2. claims: 23(completely); 26-29(partially)

Composition comprising metal oxide/hydroxide, an epoxy functional PDMS and an onium salt of a pentafluorophosphate. Processes for its manufacture. Process for its cure. Cured composition.

3. claims: 24(completely); 26-29(partially)

Composition comprising metal oxide/hydroxide, a vinyl terminated polydiphenyldimethylsiloxane and a Si-H polydimethylsiloxane. Processes for its manufacture. Process for its cure. Cured composition.

4. claim: 20

Process for manufacture of a crystalline component from an amorphous metal oxide/hydroxide, admixing with a polyorganosiloxane and heating.

INTERNATIONAL SEARCH REPORT

Information on patent family members

International application No

PCT/EP2016/001267

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